

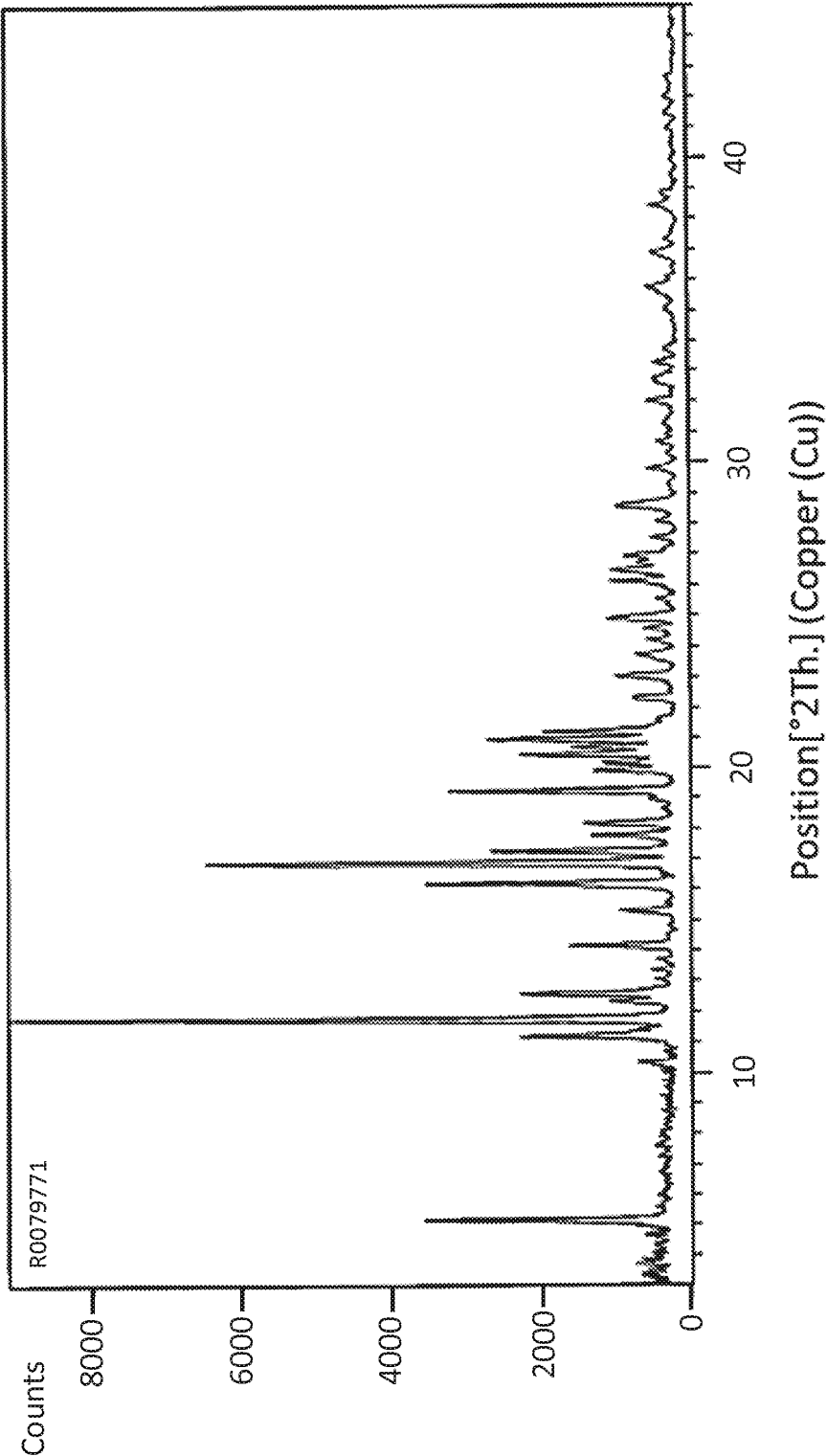


FIG. 1A

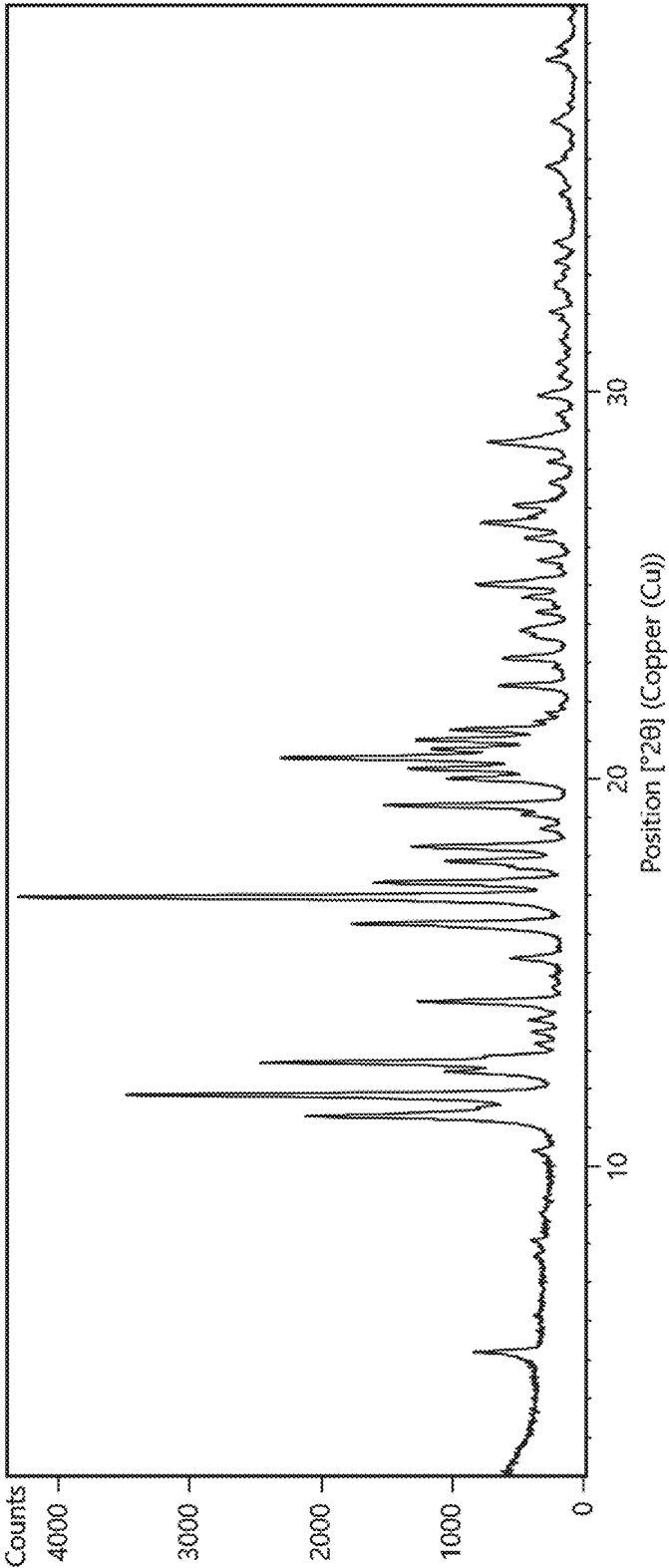


FIG. 1B

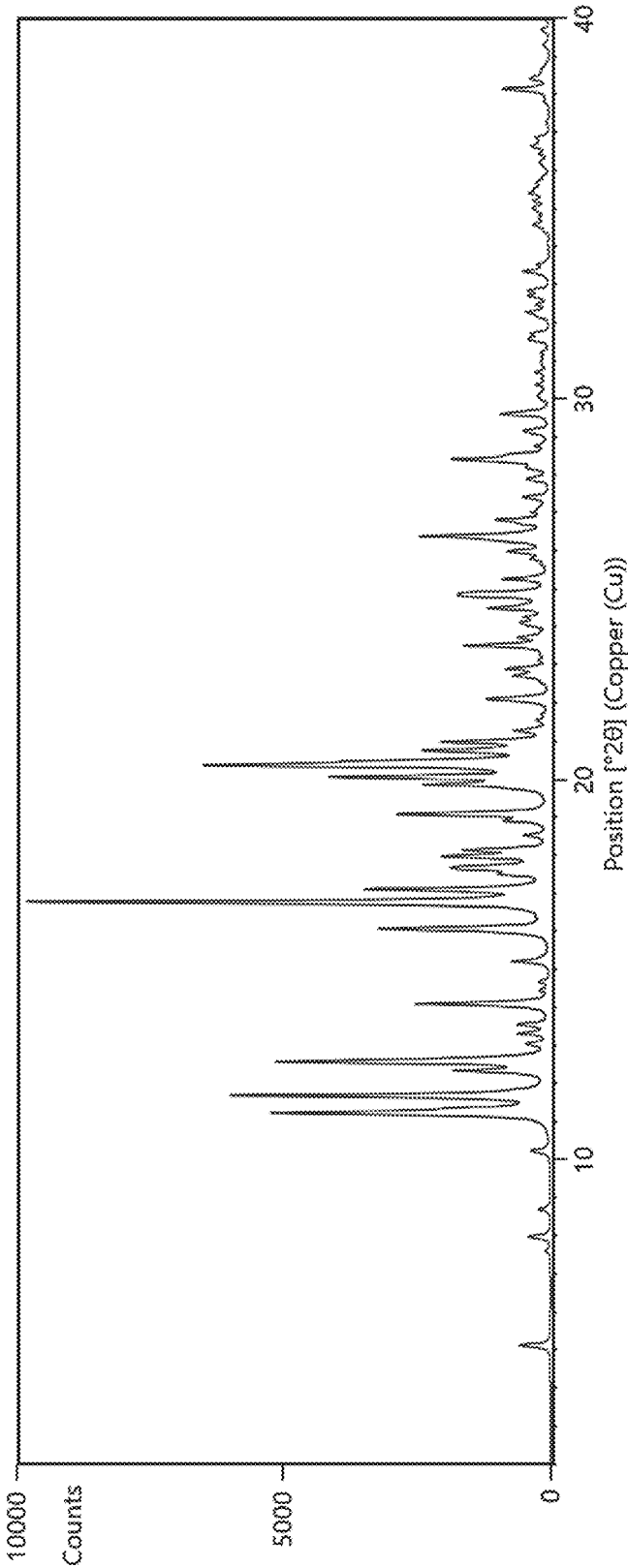


FIG. 1C

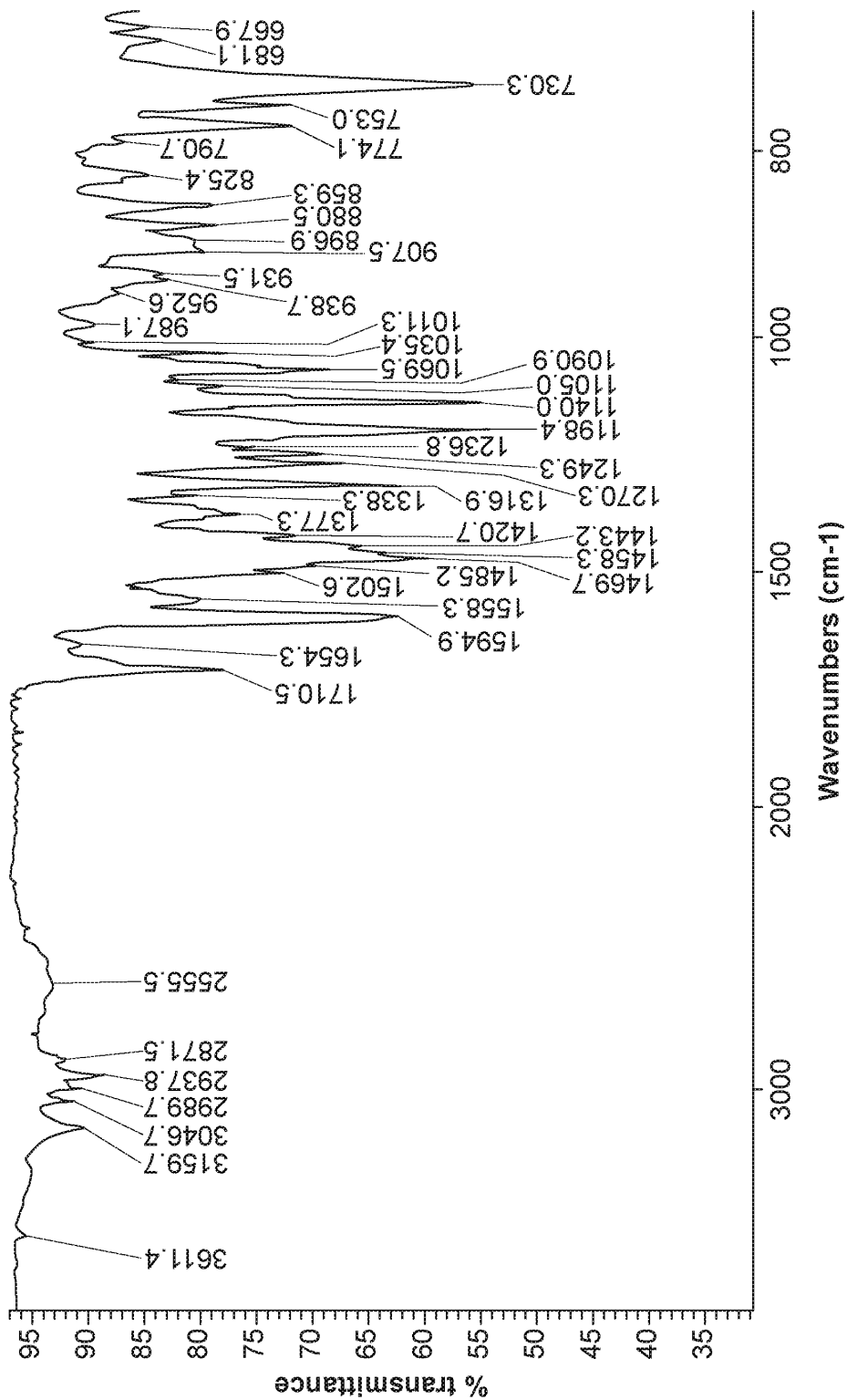


FIG. 2

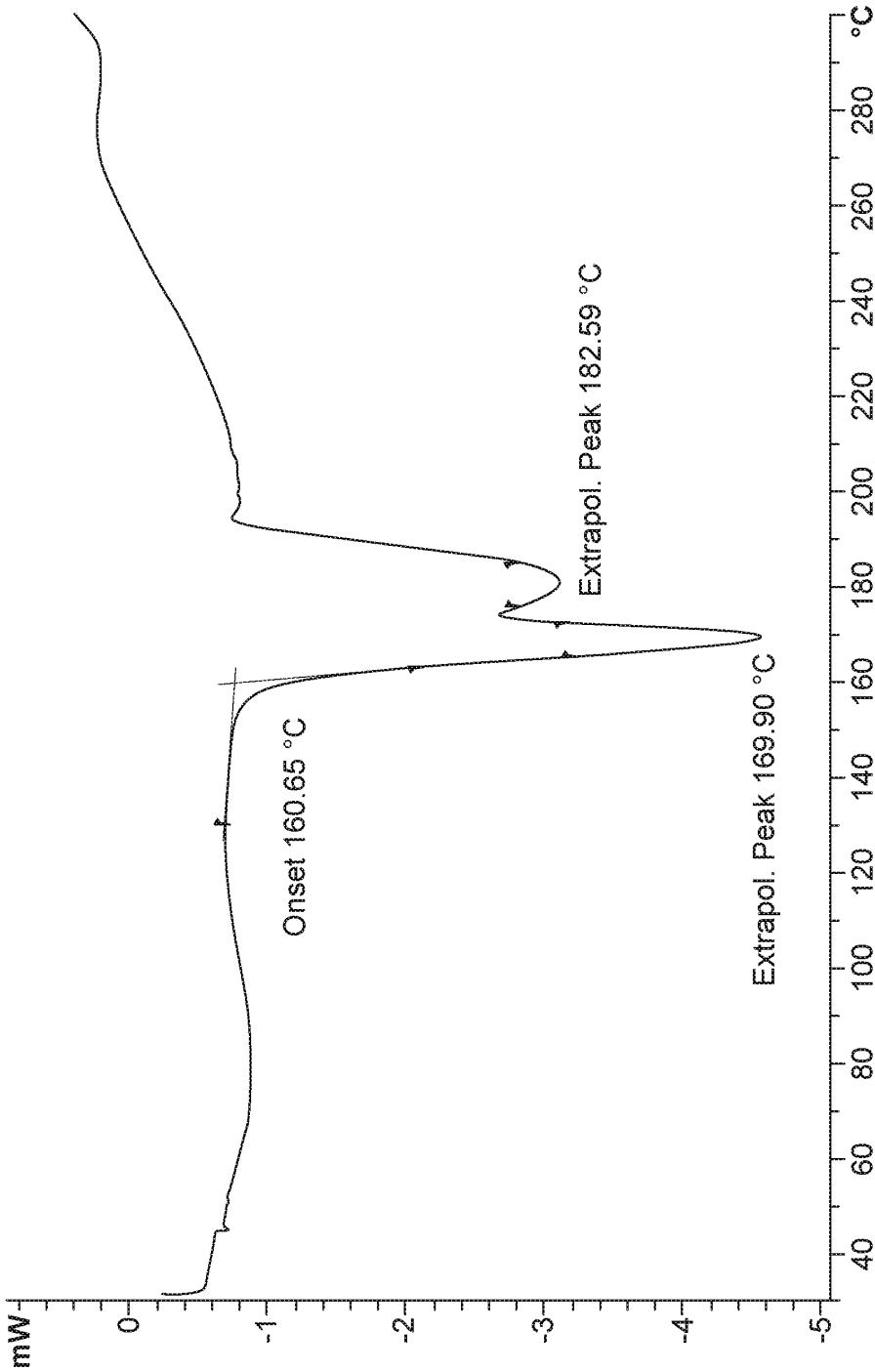


FIG. 3

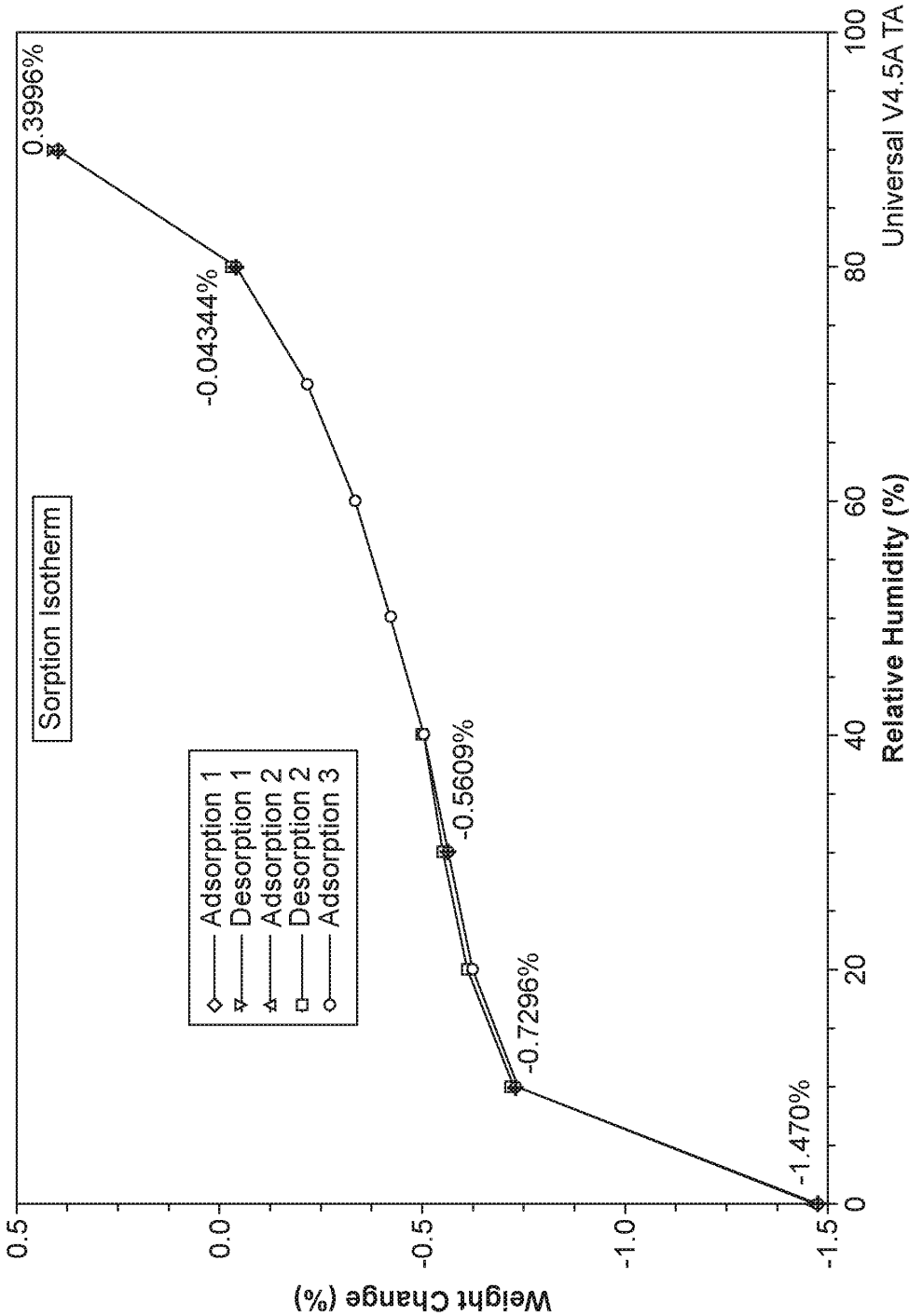
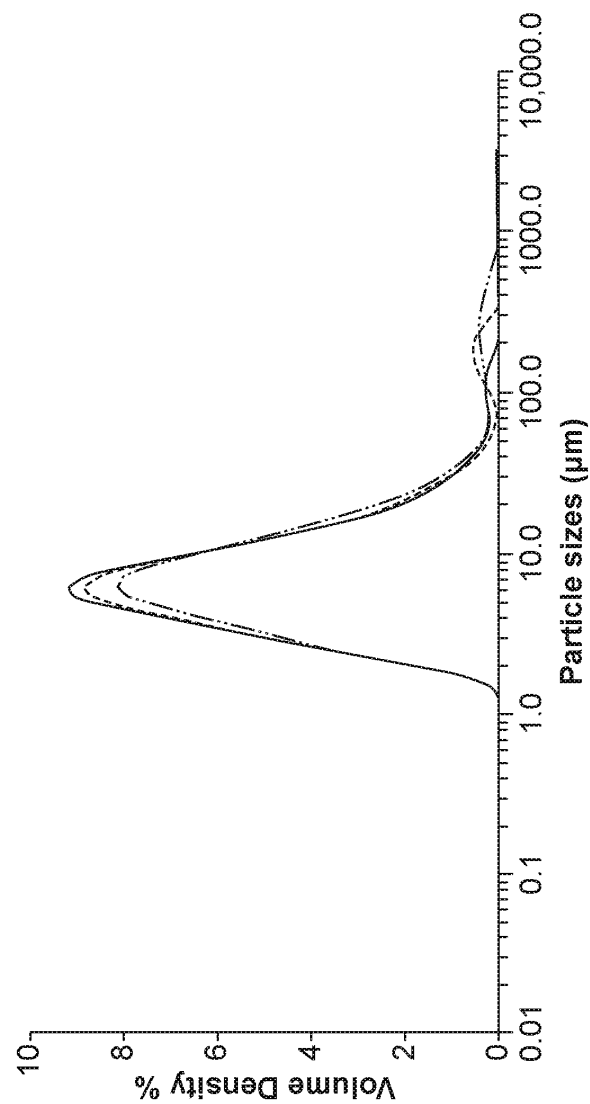


FIG. 4



	Record No.	Dx (10) (μm)	Dx (50) (μm)	Dx (90) (μm)	D [4,3] (μm)	Laser Obscuration (%)
	1	2.95	7.15	23.9	20.9	12.47
	2	2.93	6.67	19.5	13.9	12.83
	3	2.93	6.51	17.6	10.1	13.00
Mean		2.94	6.78	20.3	15.01	12.76
1xStd Dev		0.0139	0.335	3.26	5.47	0.27
1xRSD (%)		0.472	4.94	16.0	36.6	2.13

FIG. 5

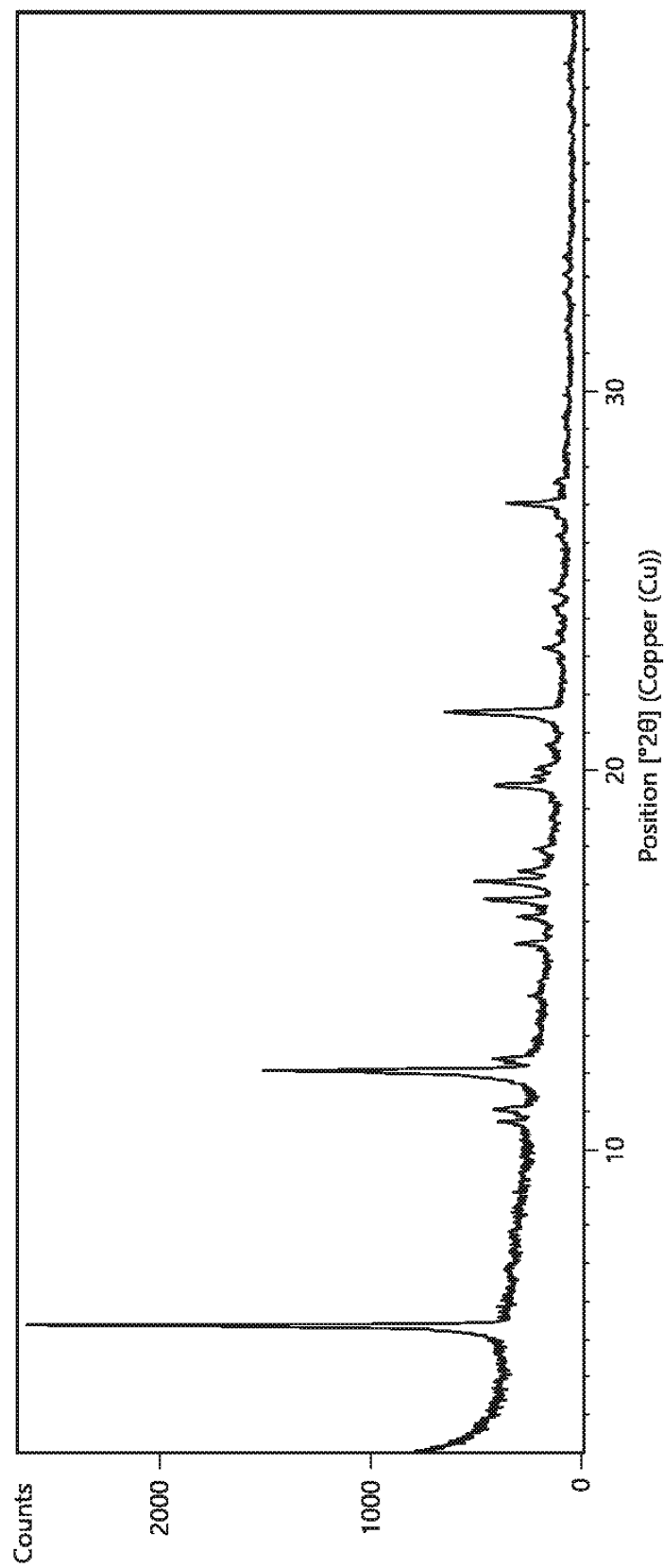


FIG. 6A

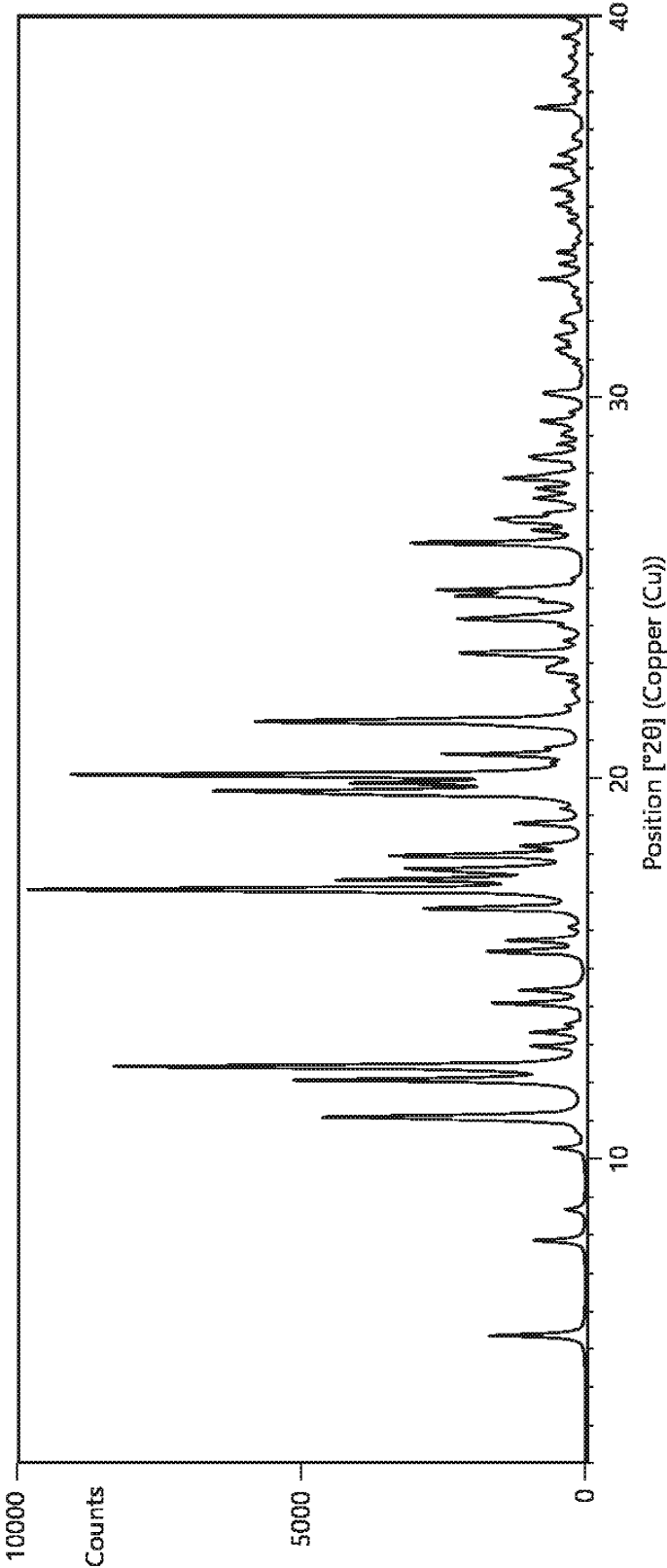


FIG. 6B

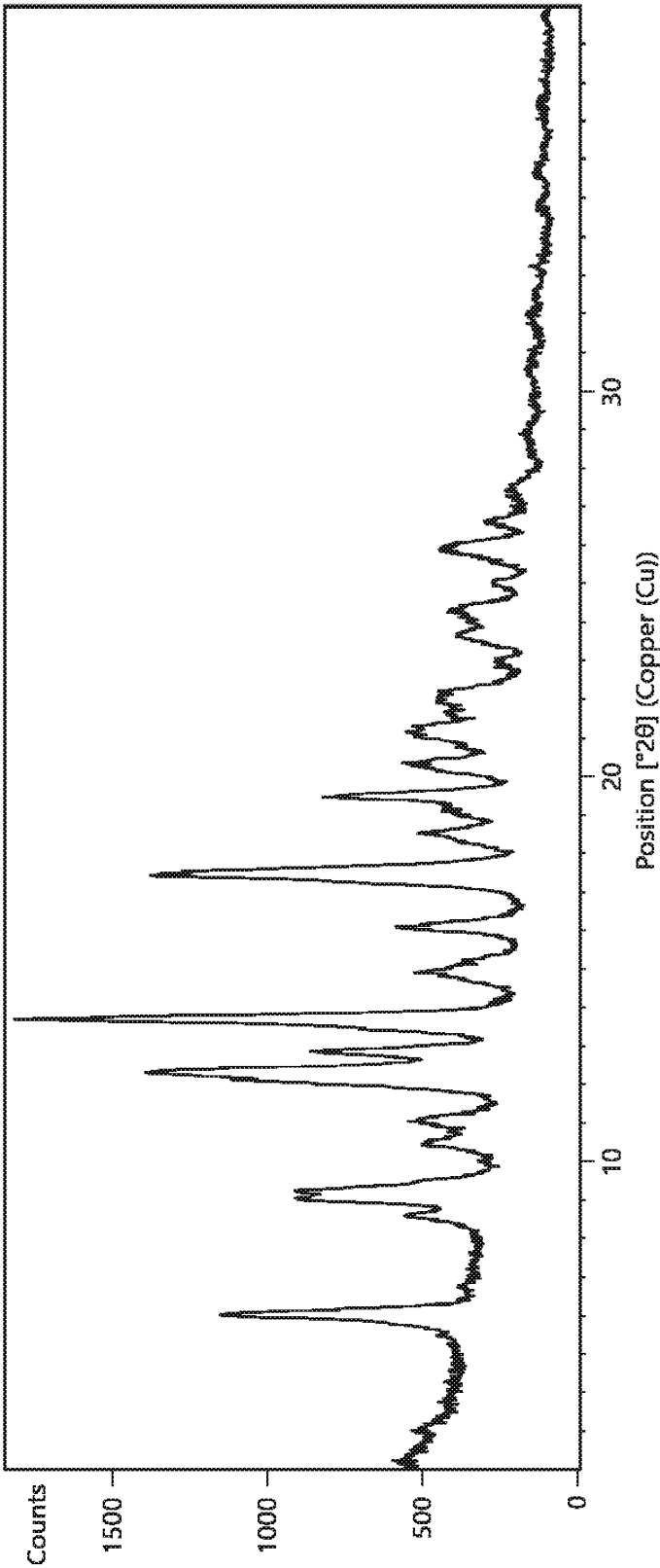


FIG. 7

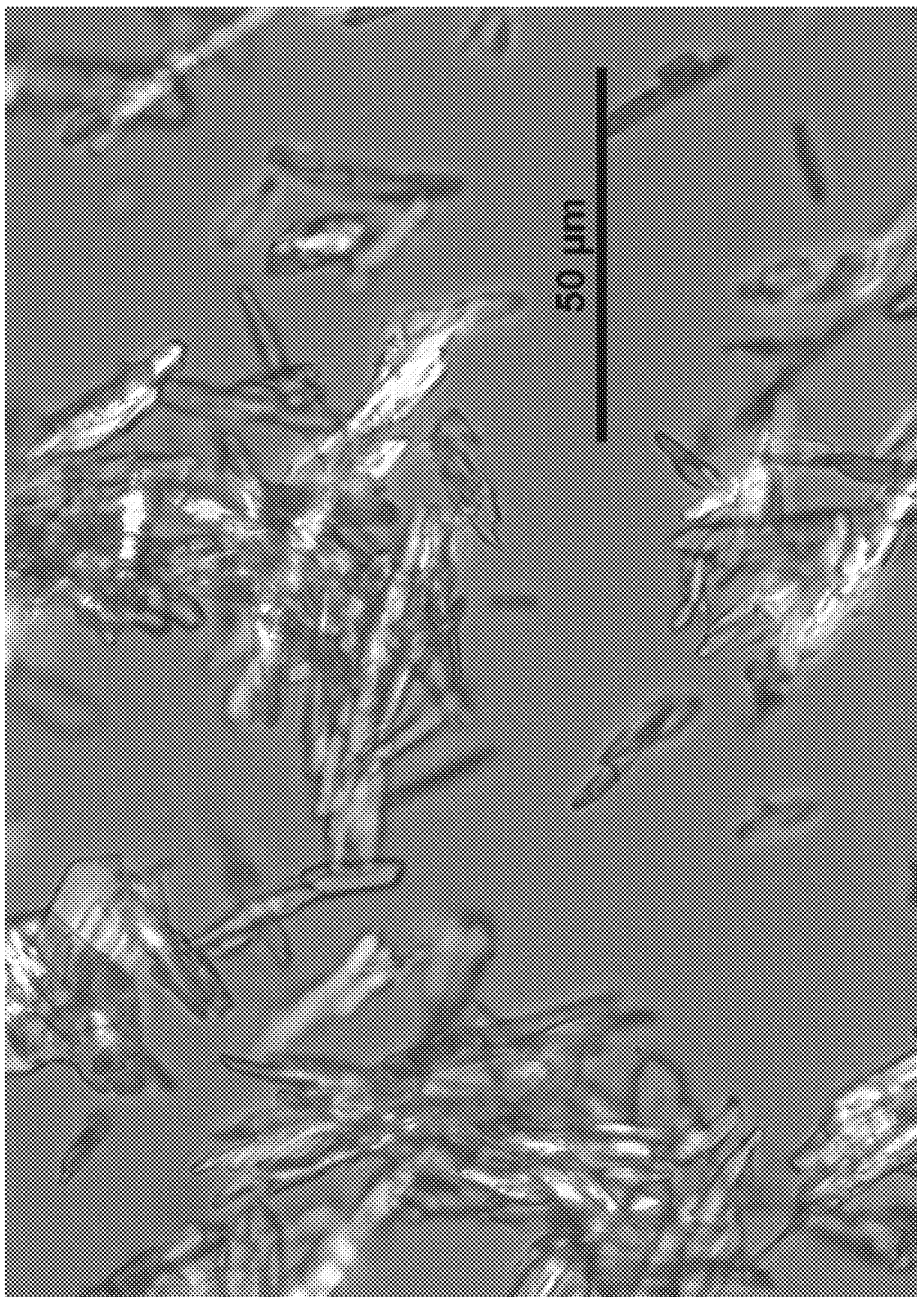


FIG. 8

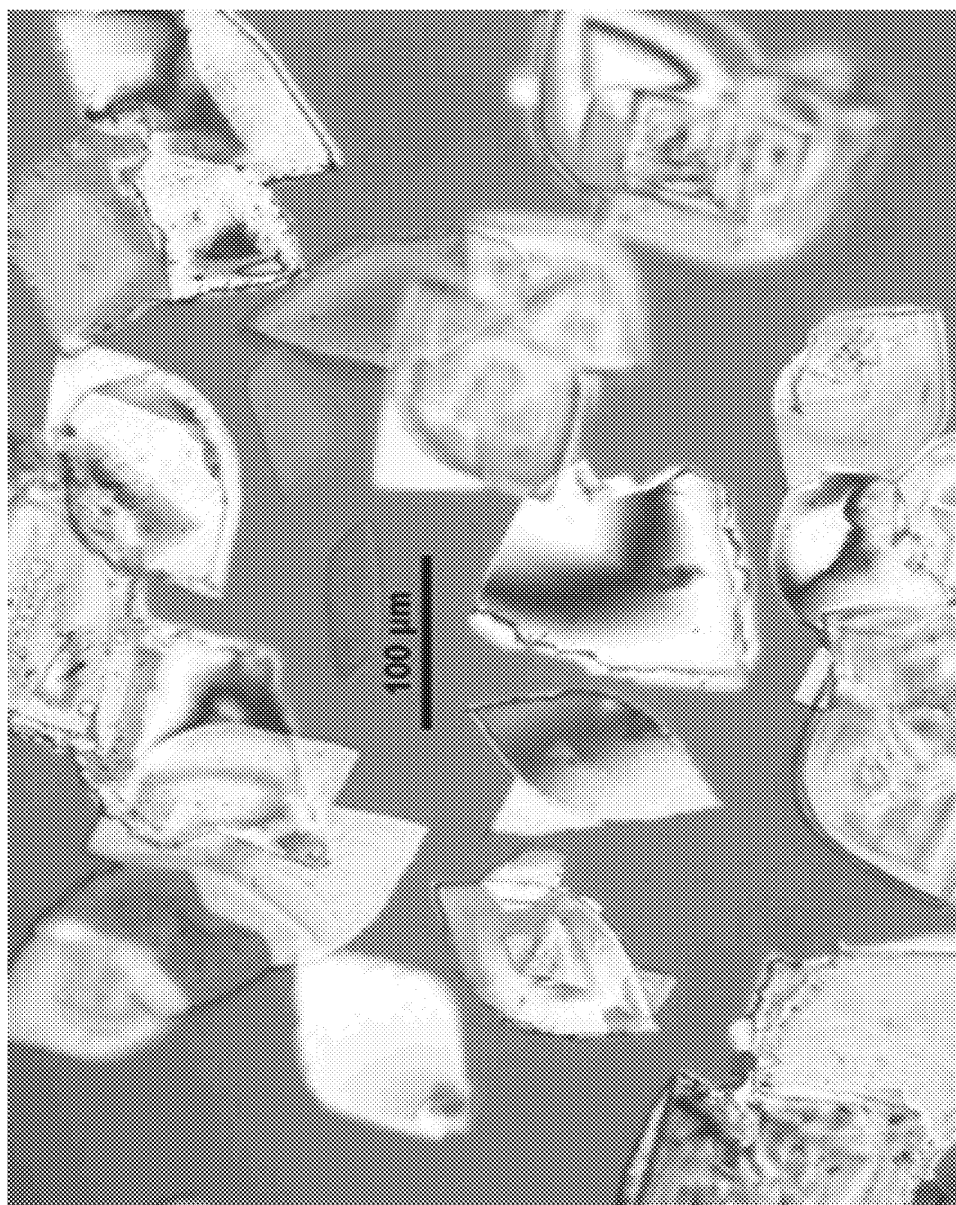


FIG. 9

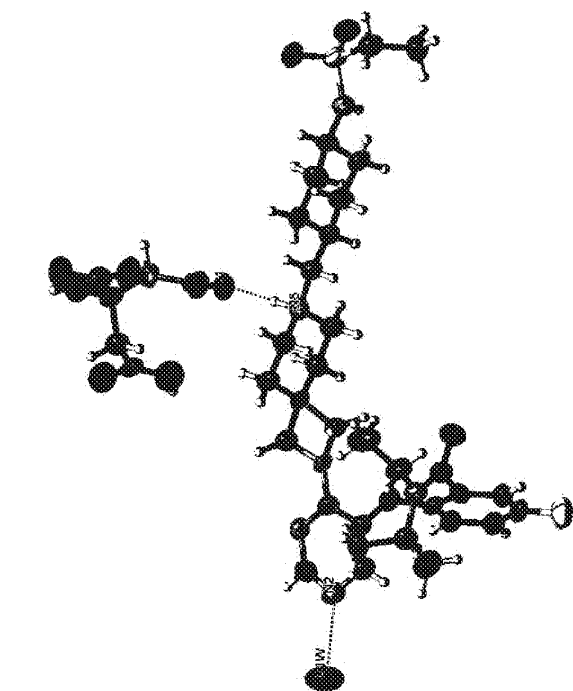


FIG. 11

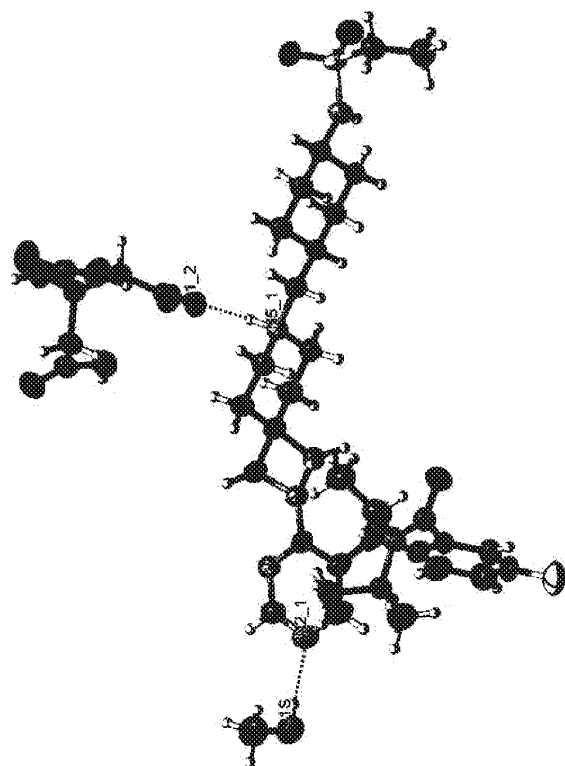


FIG. 10

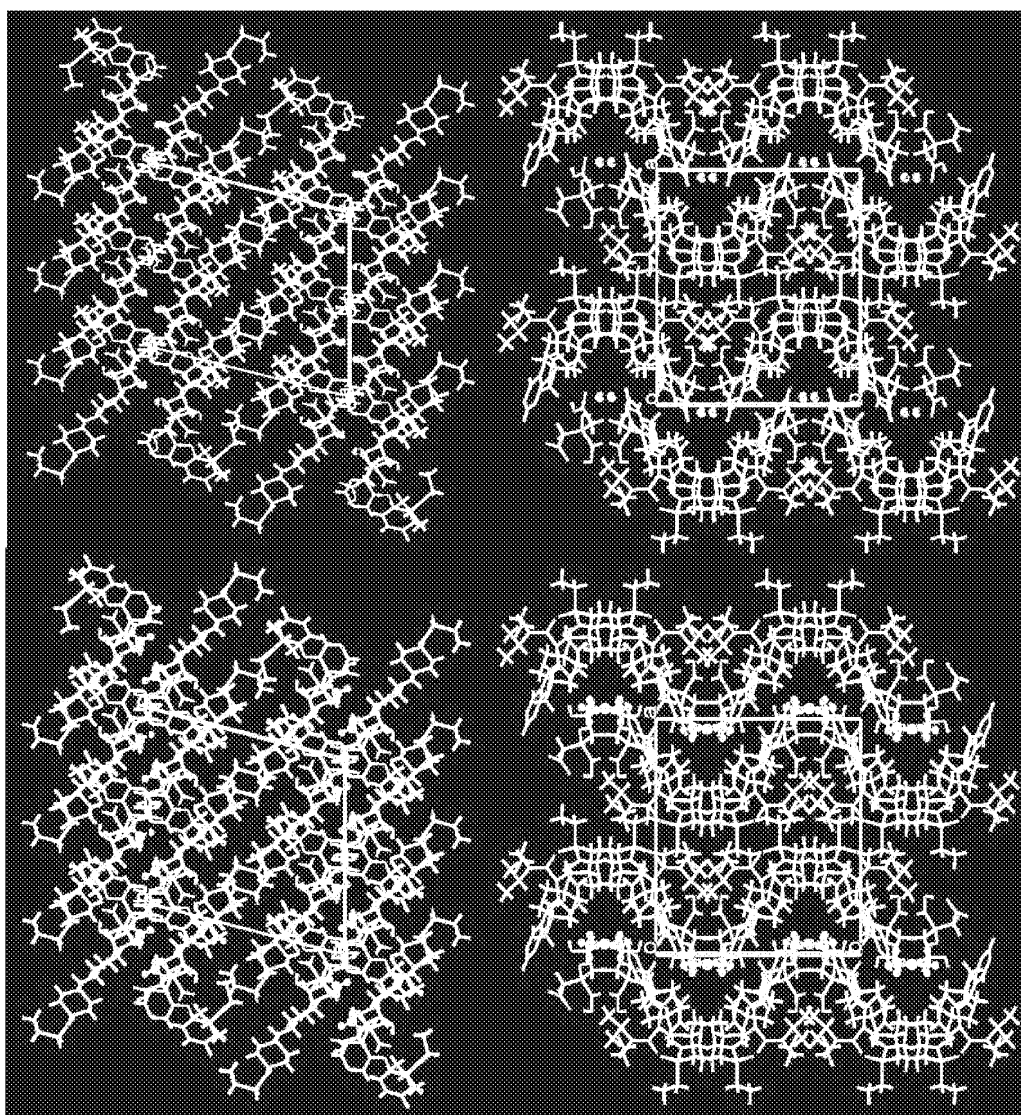


FIG. 12

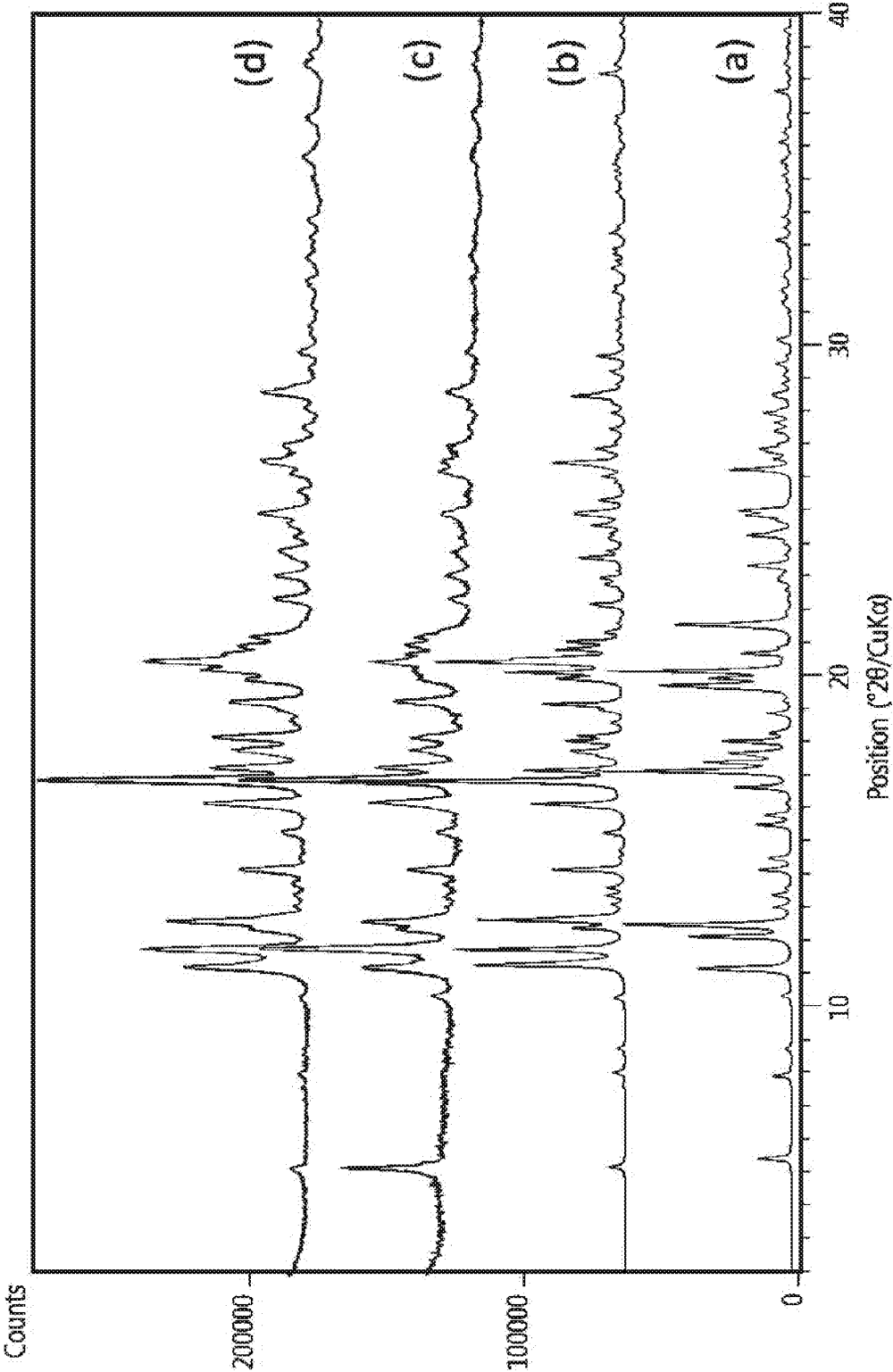


FIG. 13

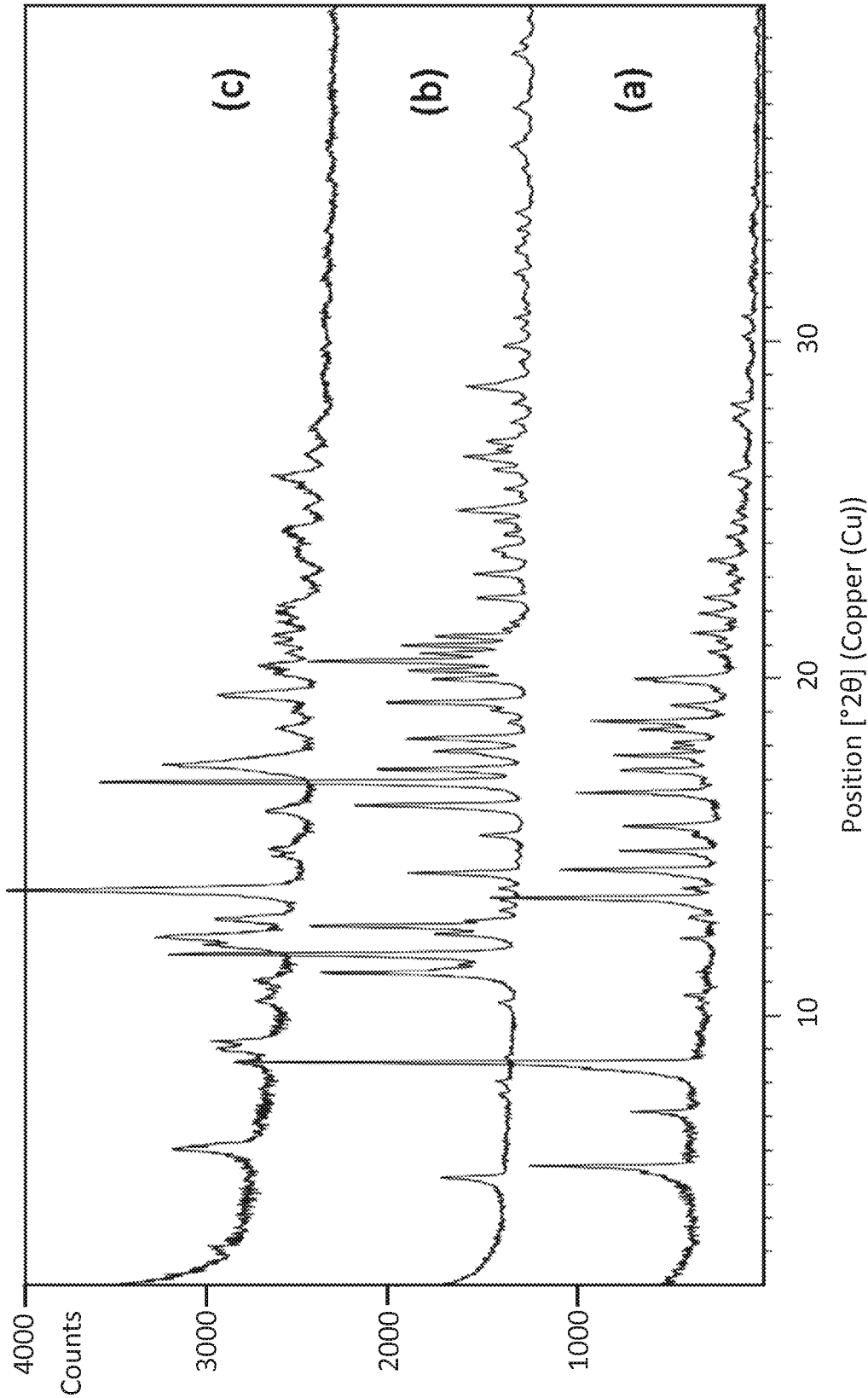


FIG. 14

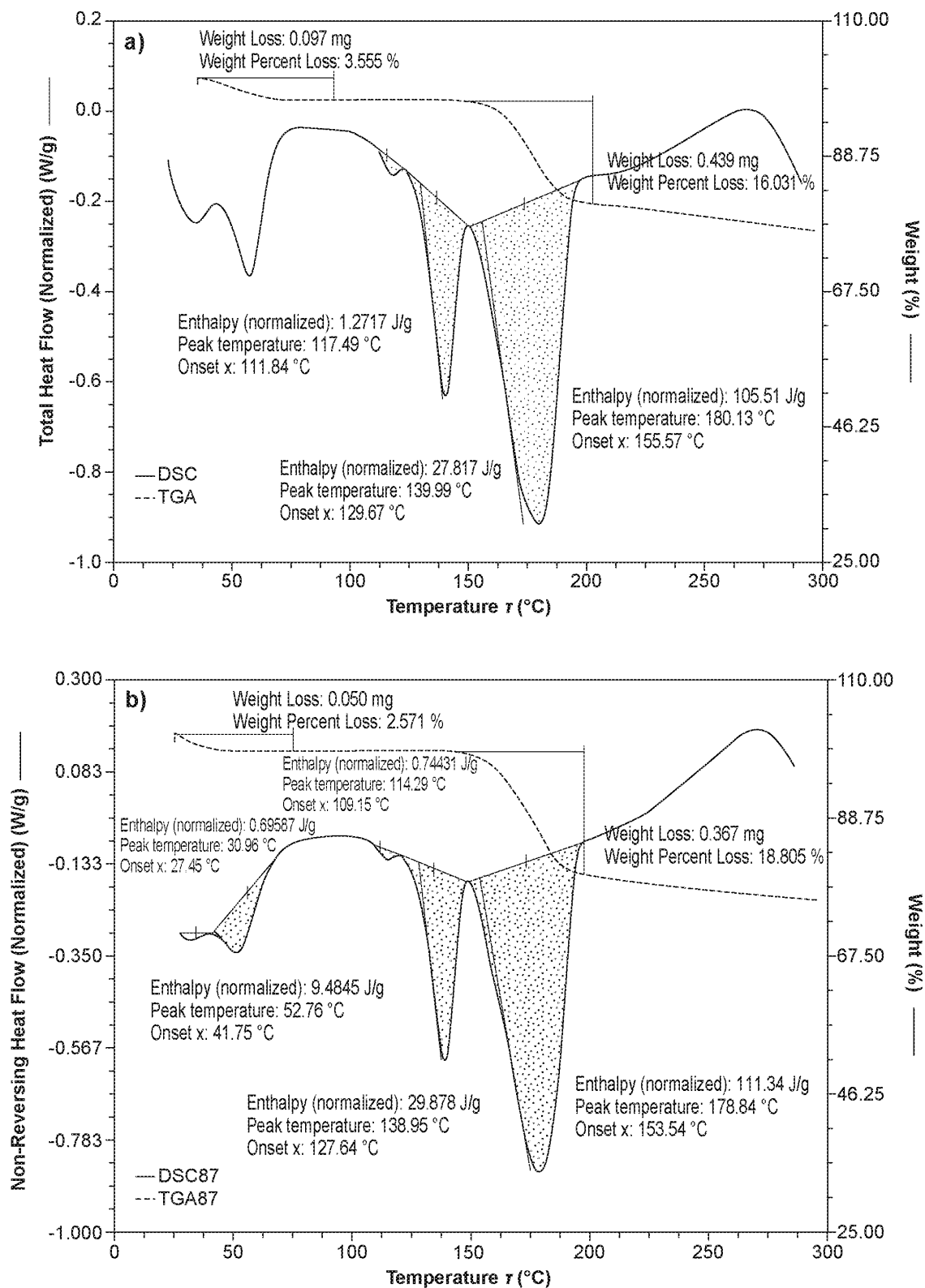


FIG. 15

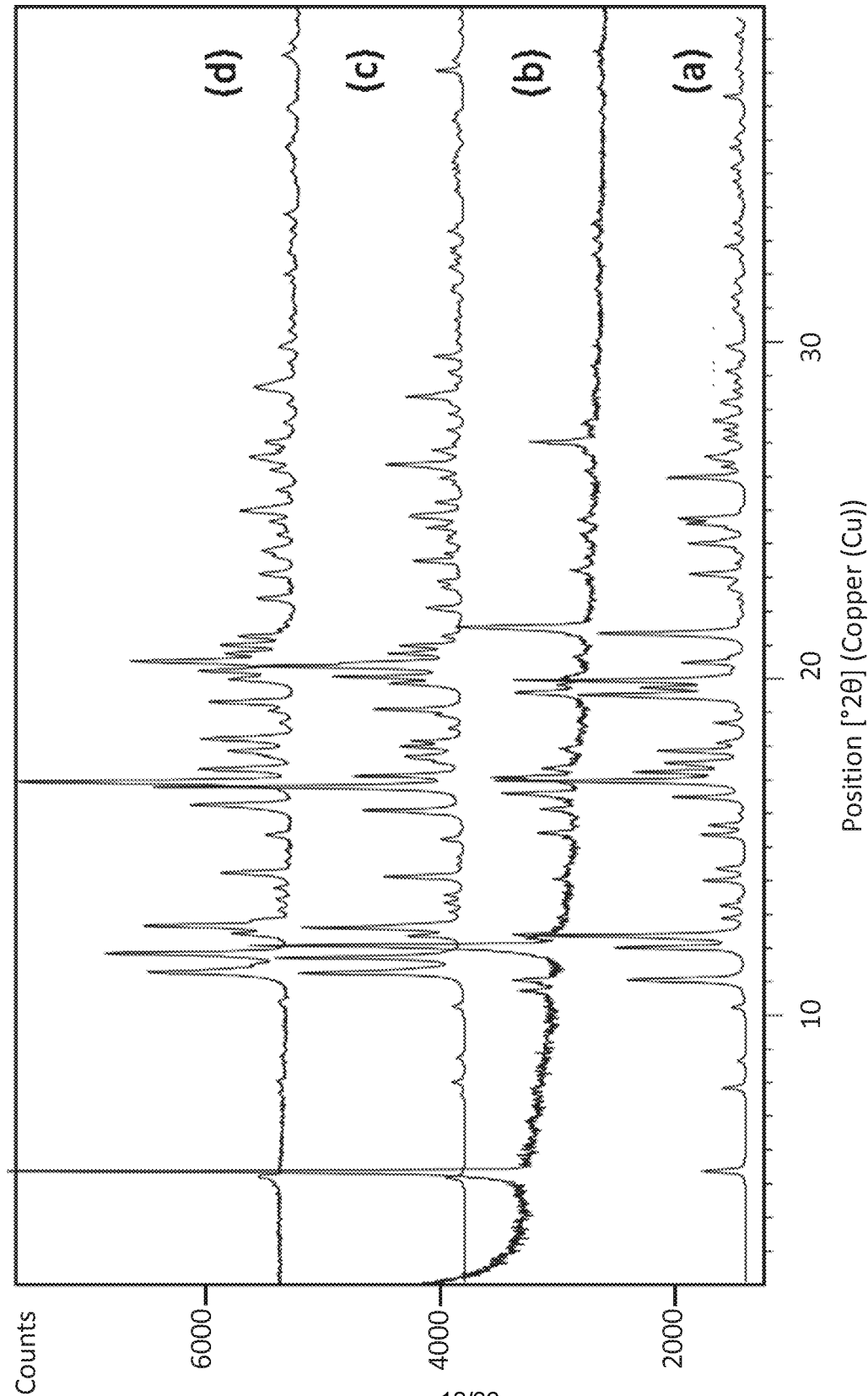


FIG. 16

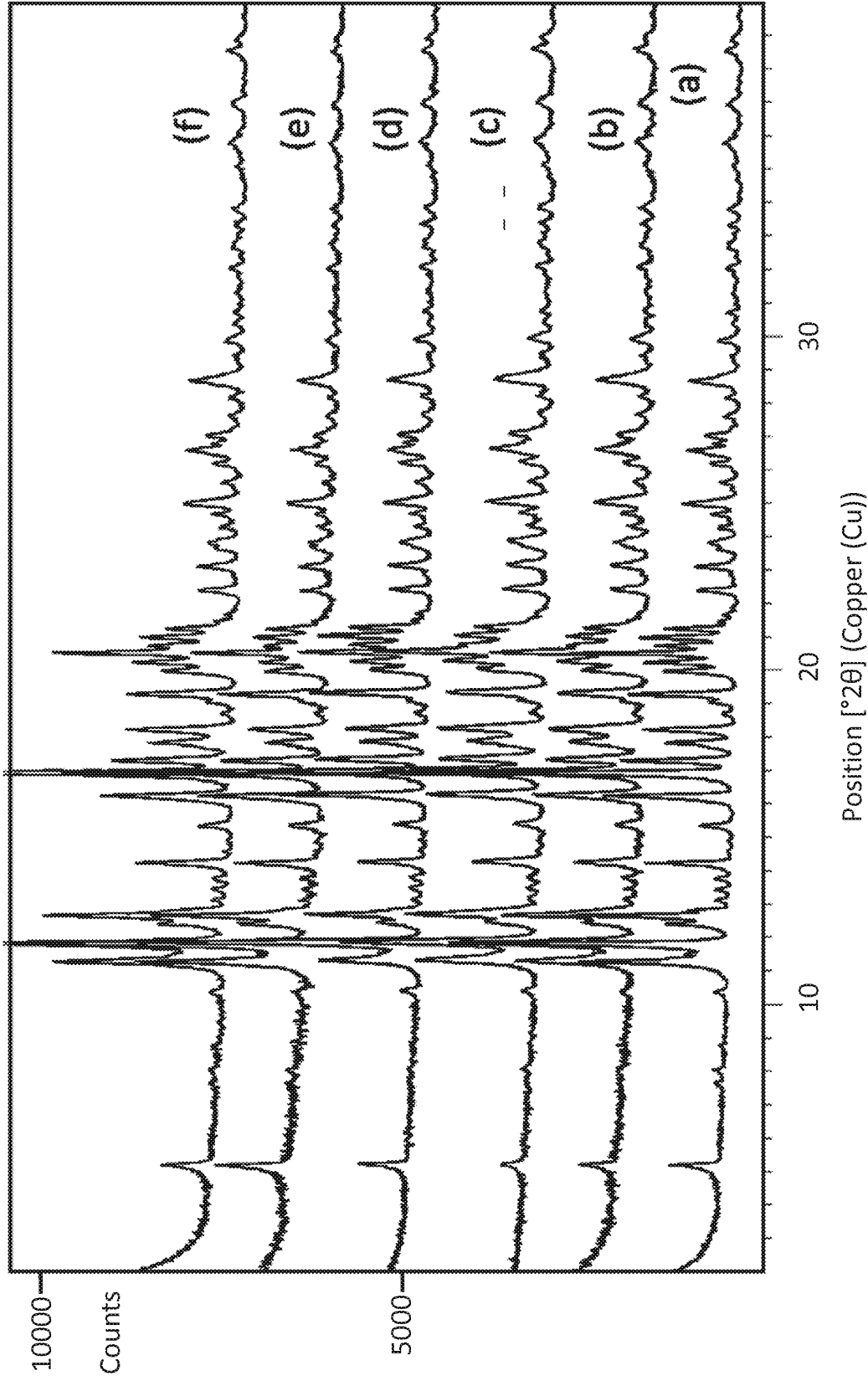


FIG. 17

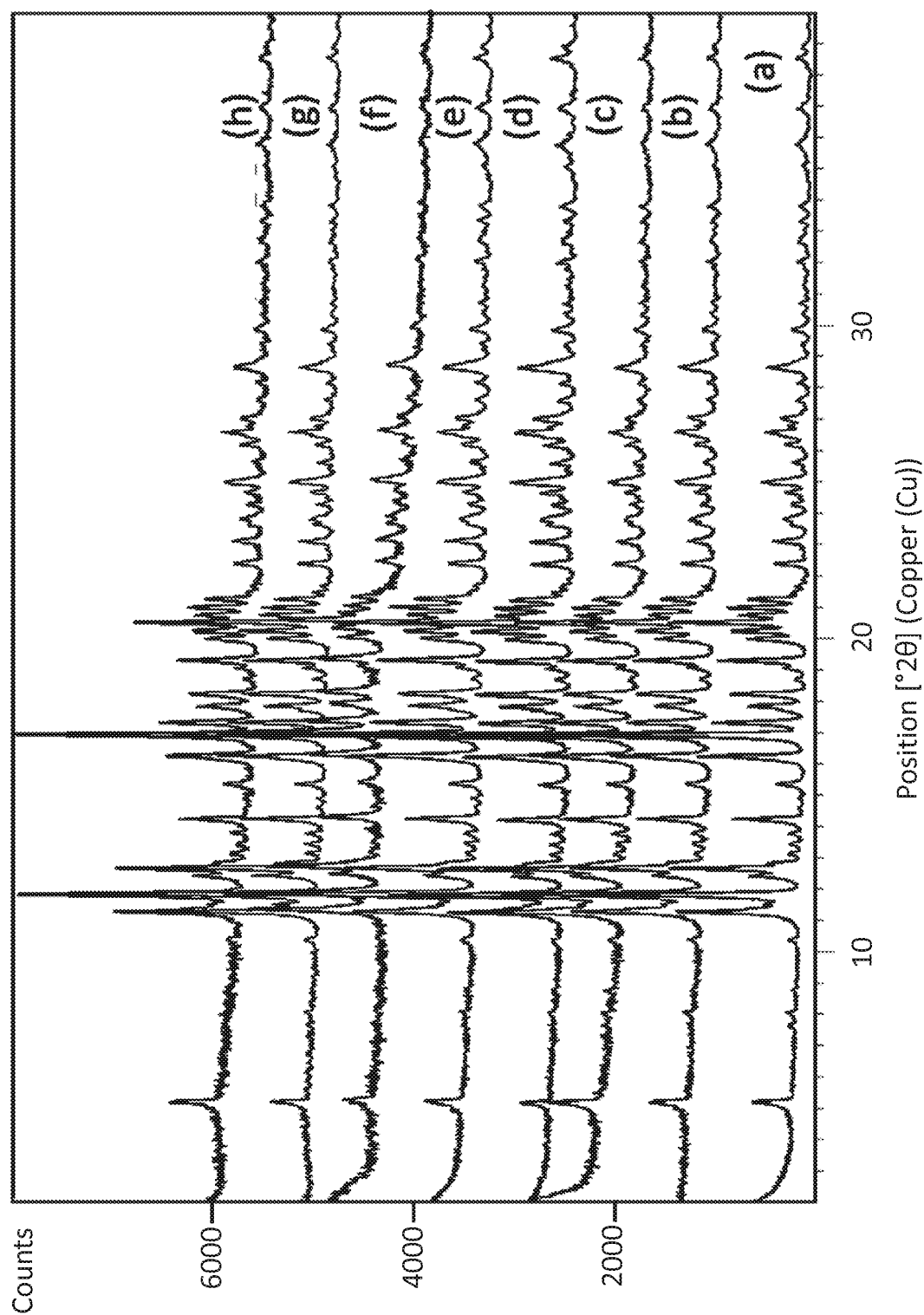


FIG. 18

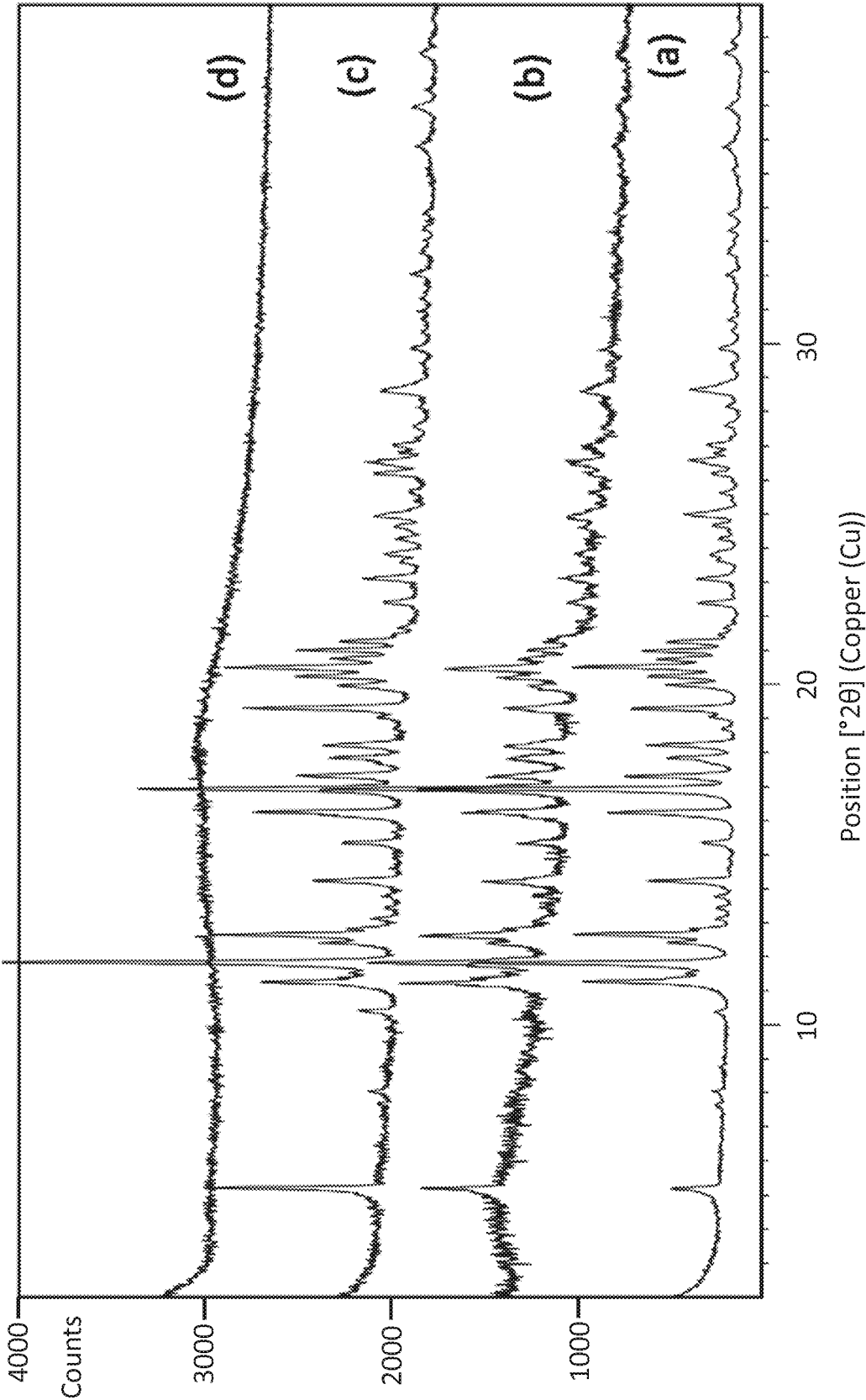


FIG. 19

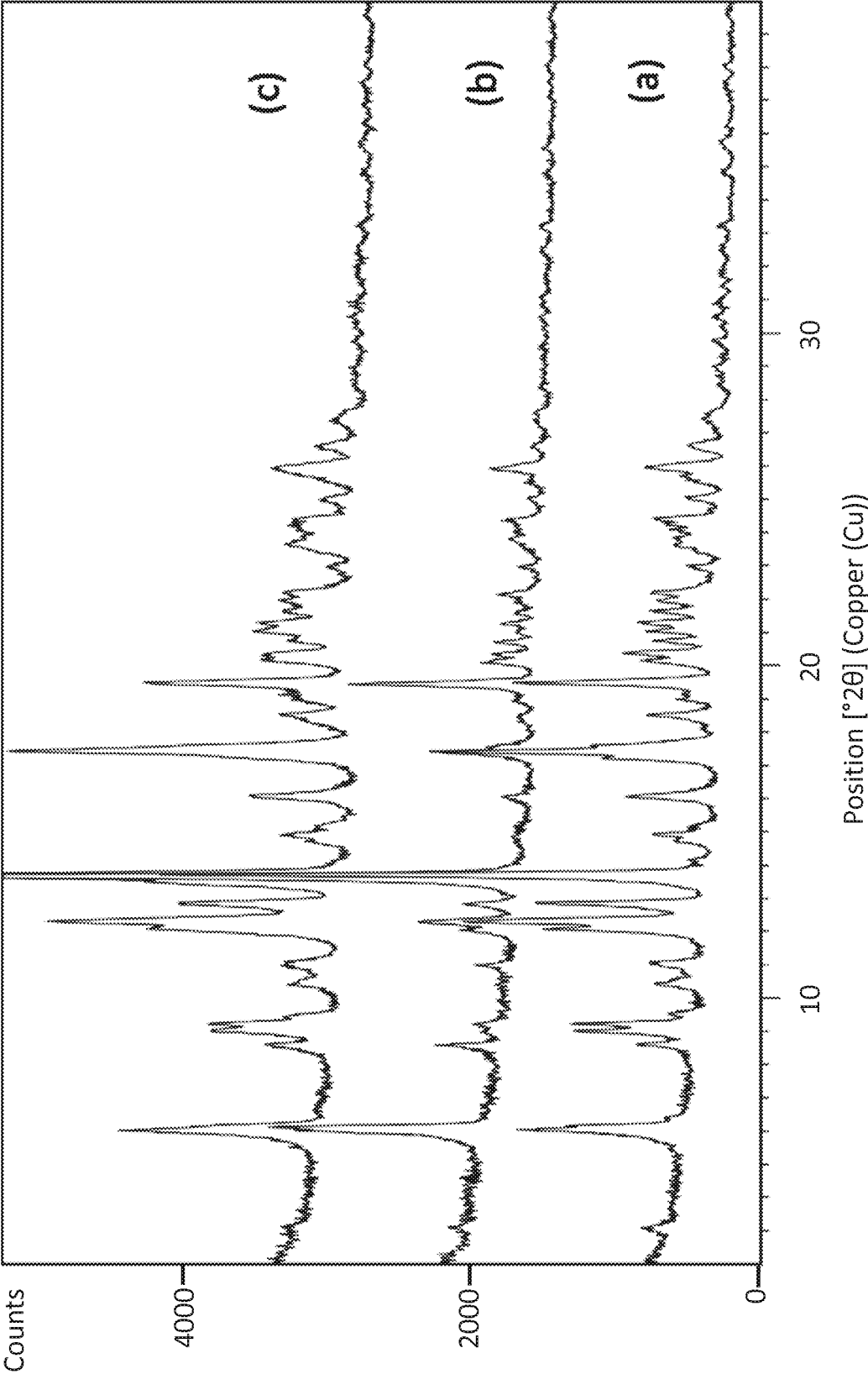


FIG. 20

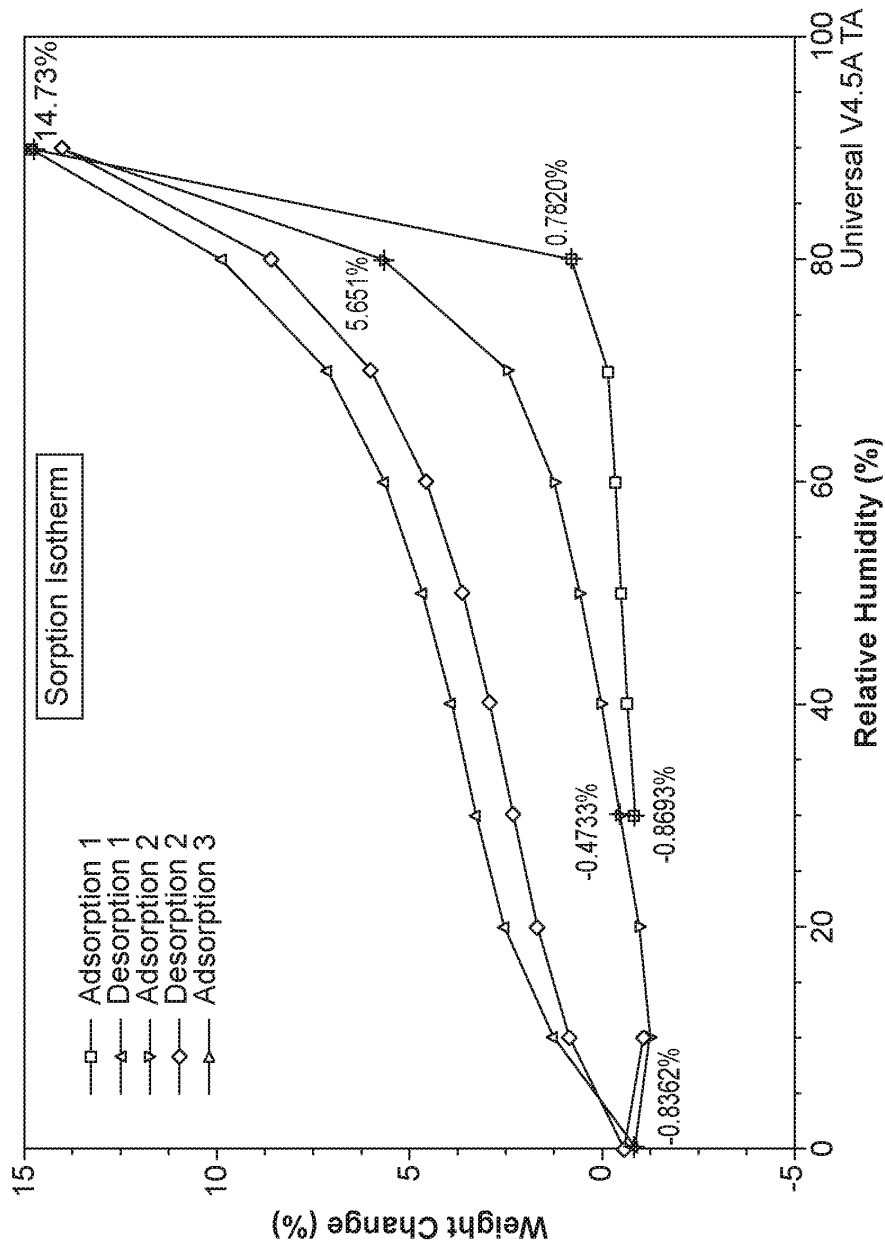


FIG. 21

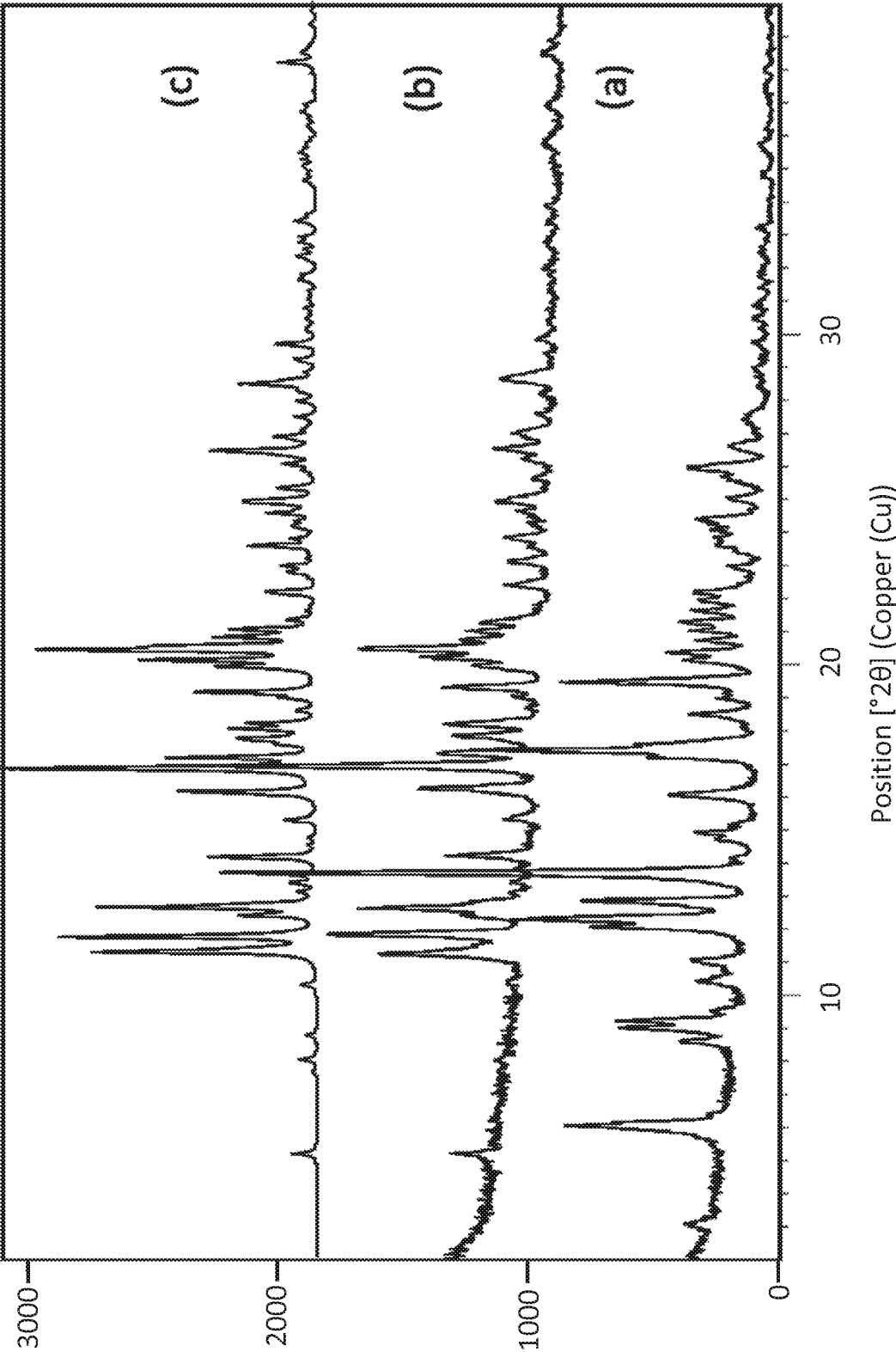


FIG. 22

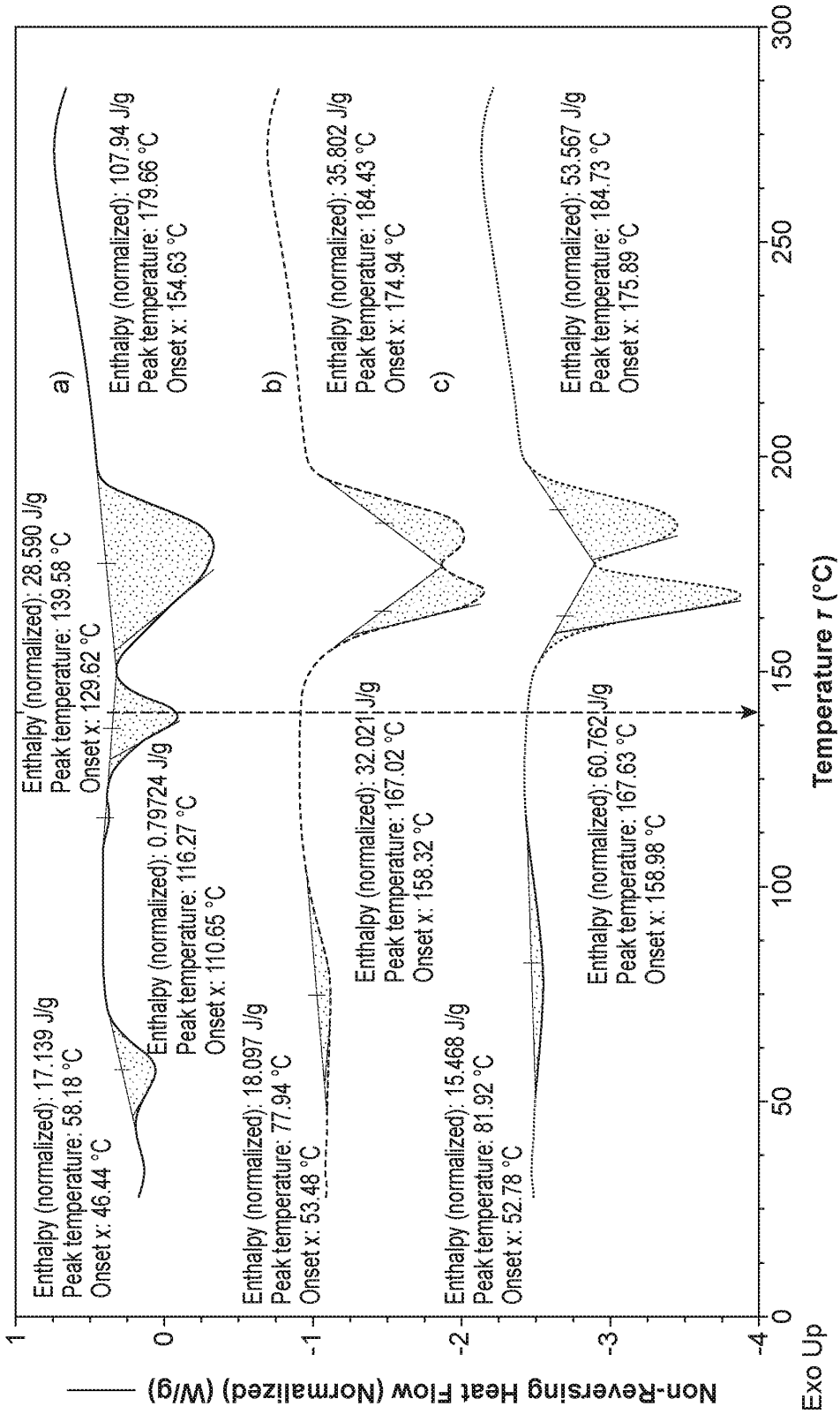


FIG. 23

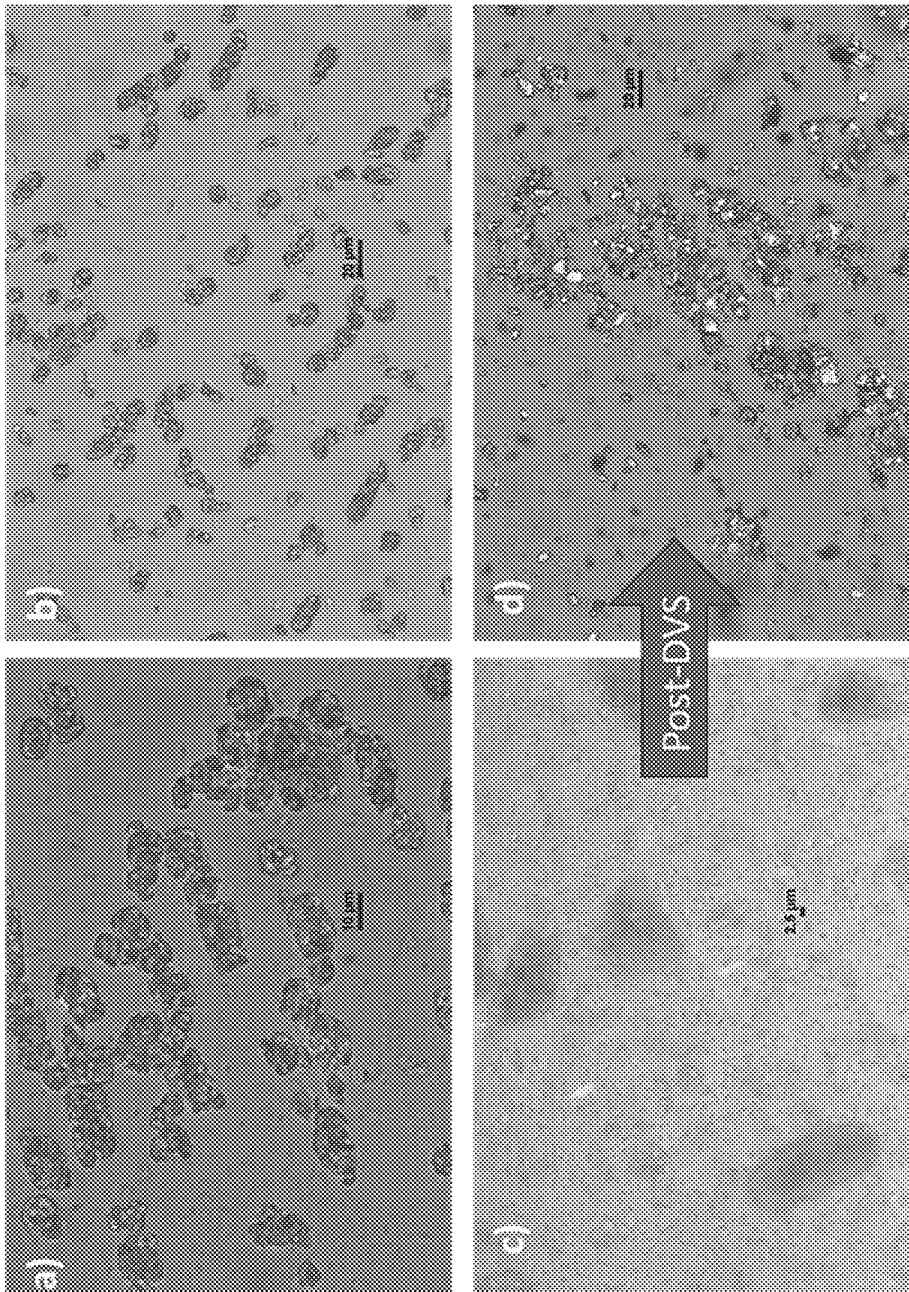


FIG. 24

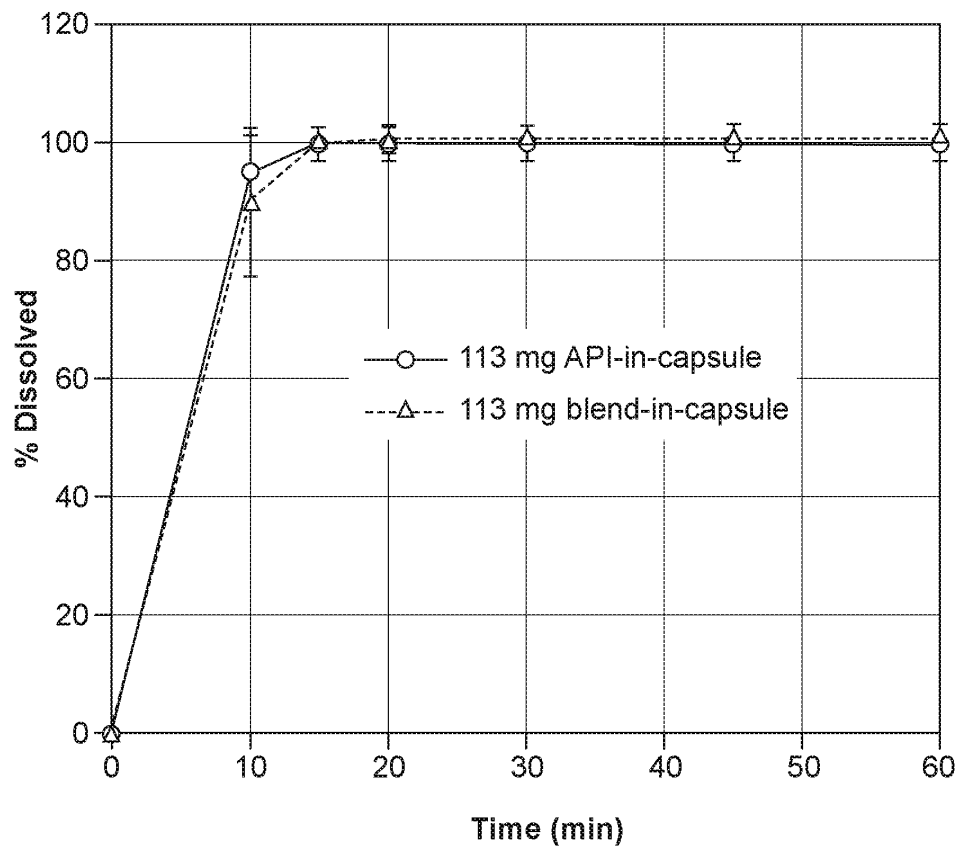


FIG. 25

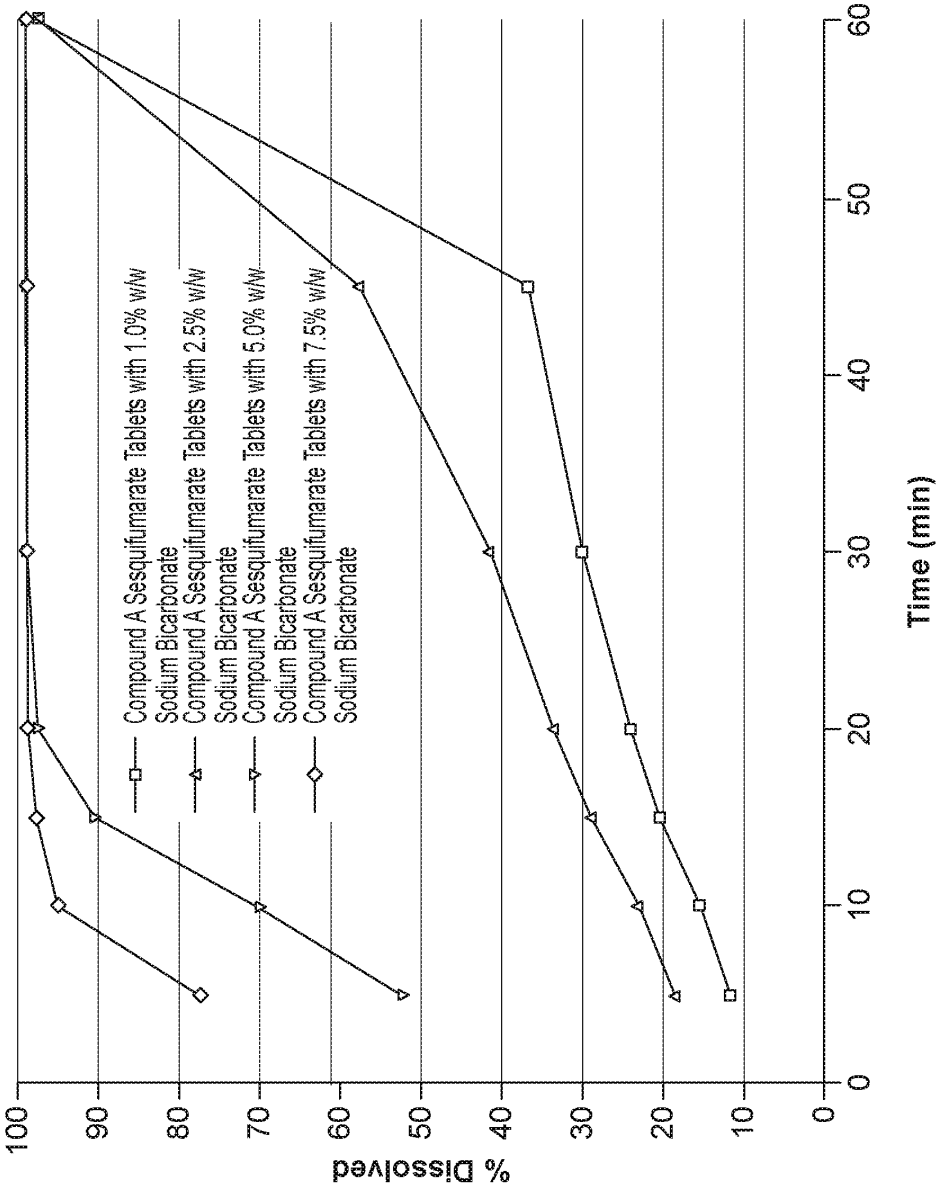


FIG. 26

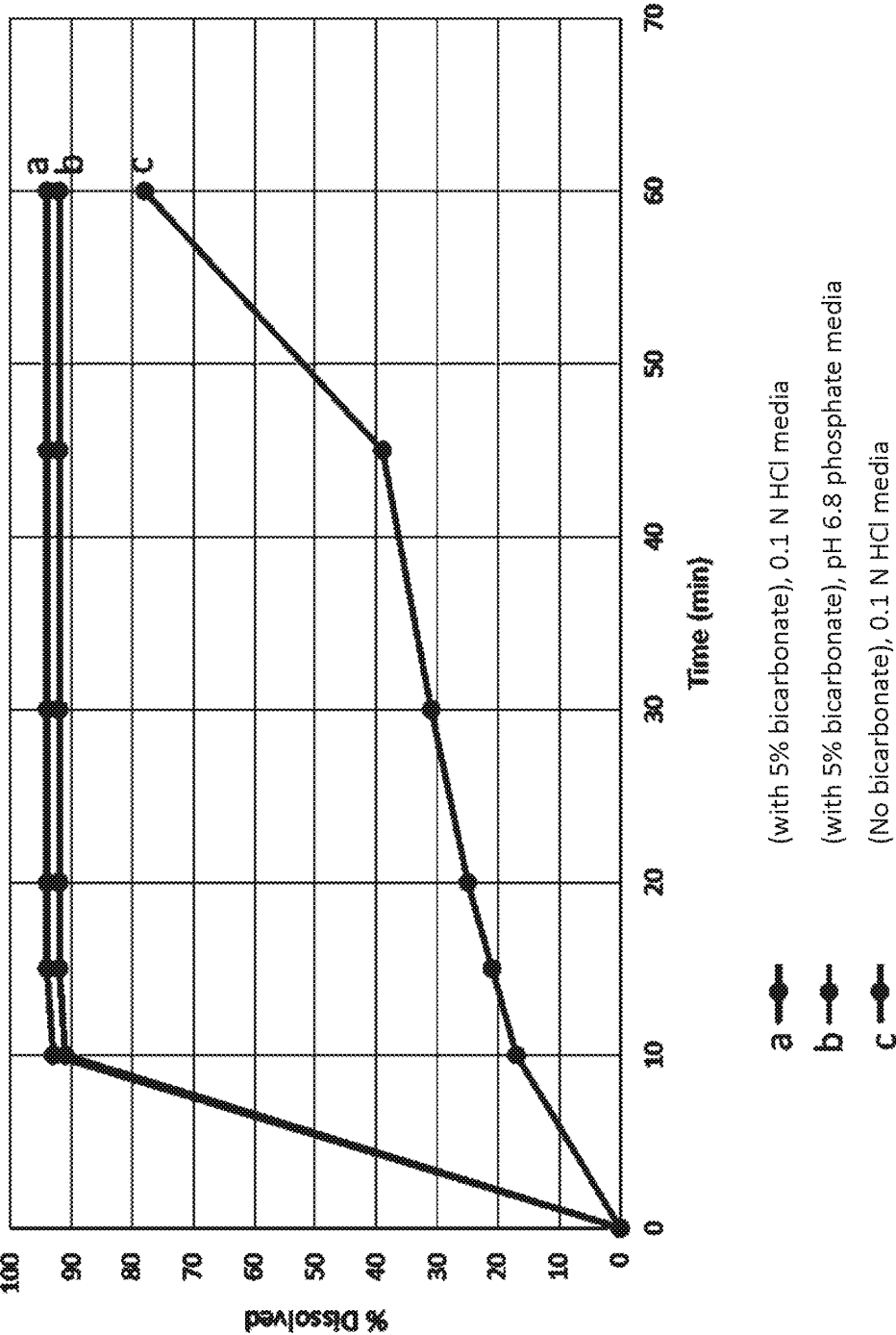


FIG. 27

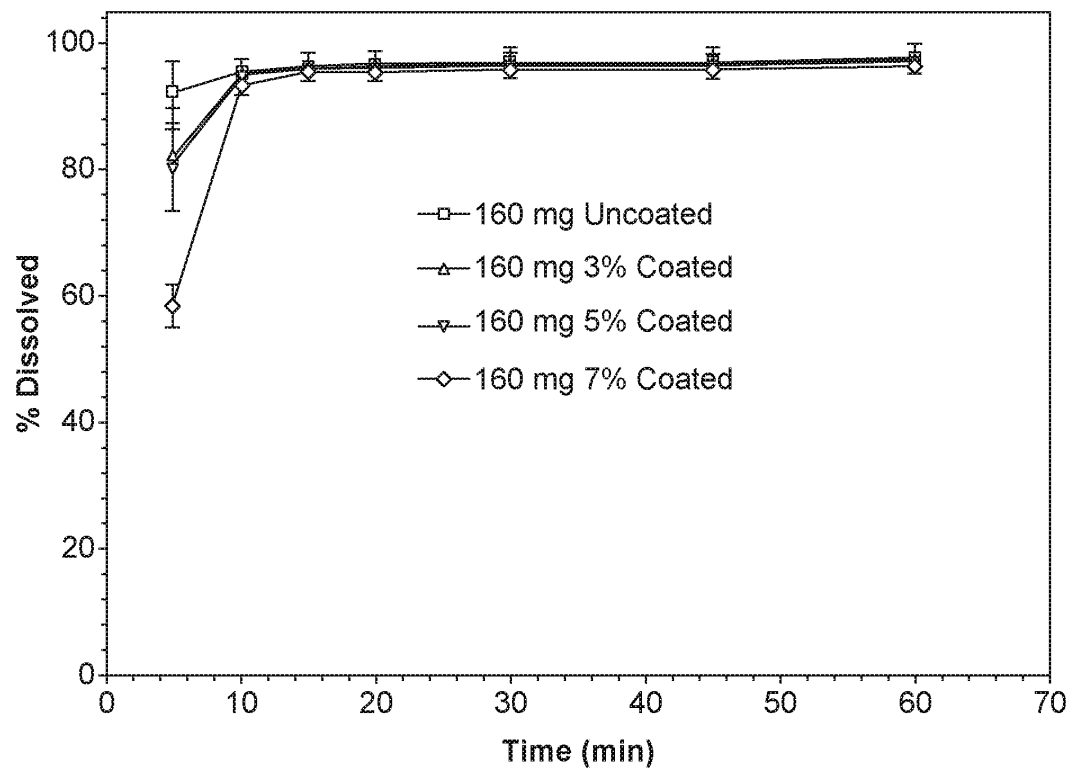


FIG. 28

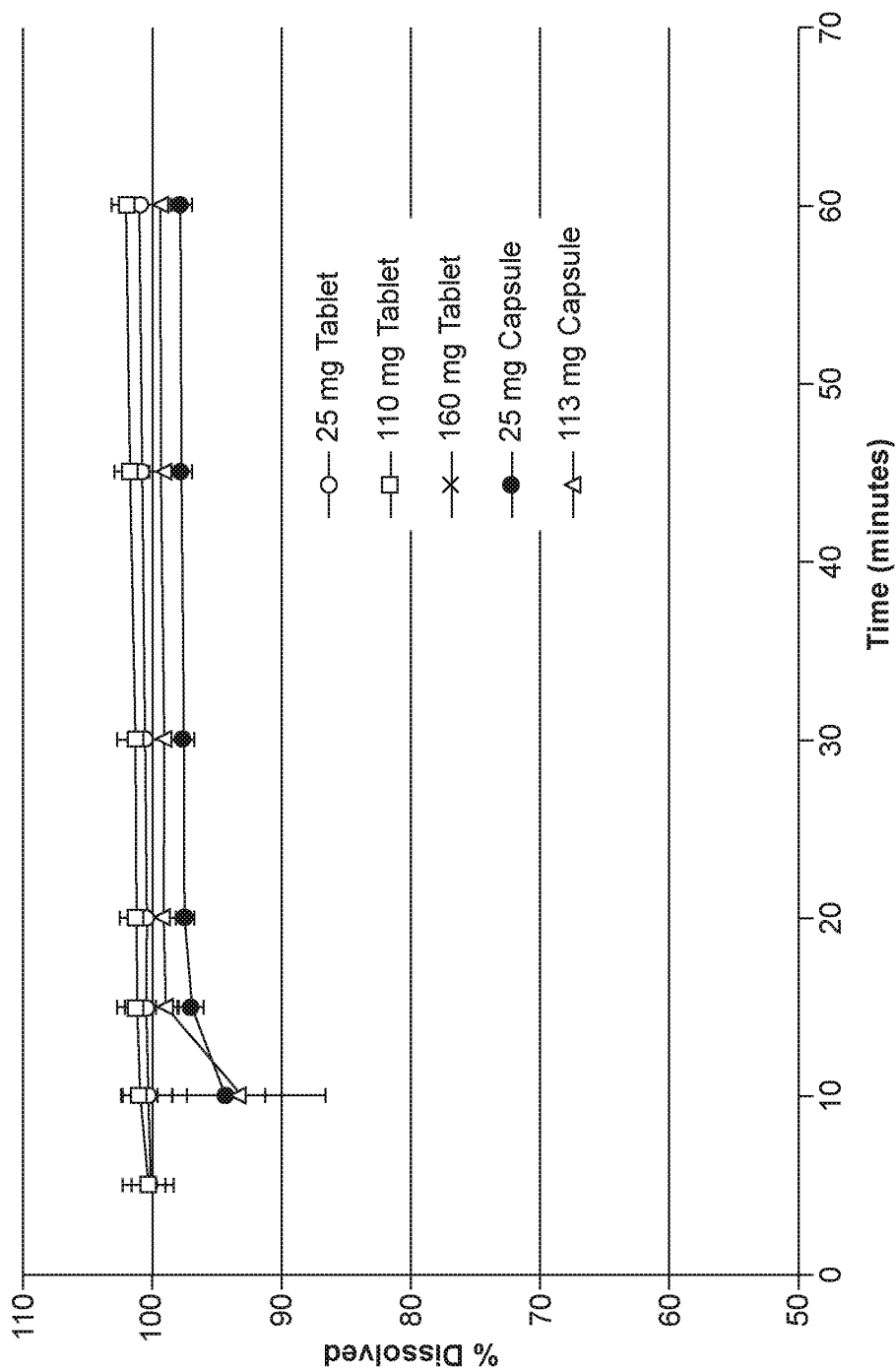


FIG. 29

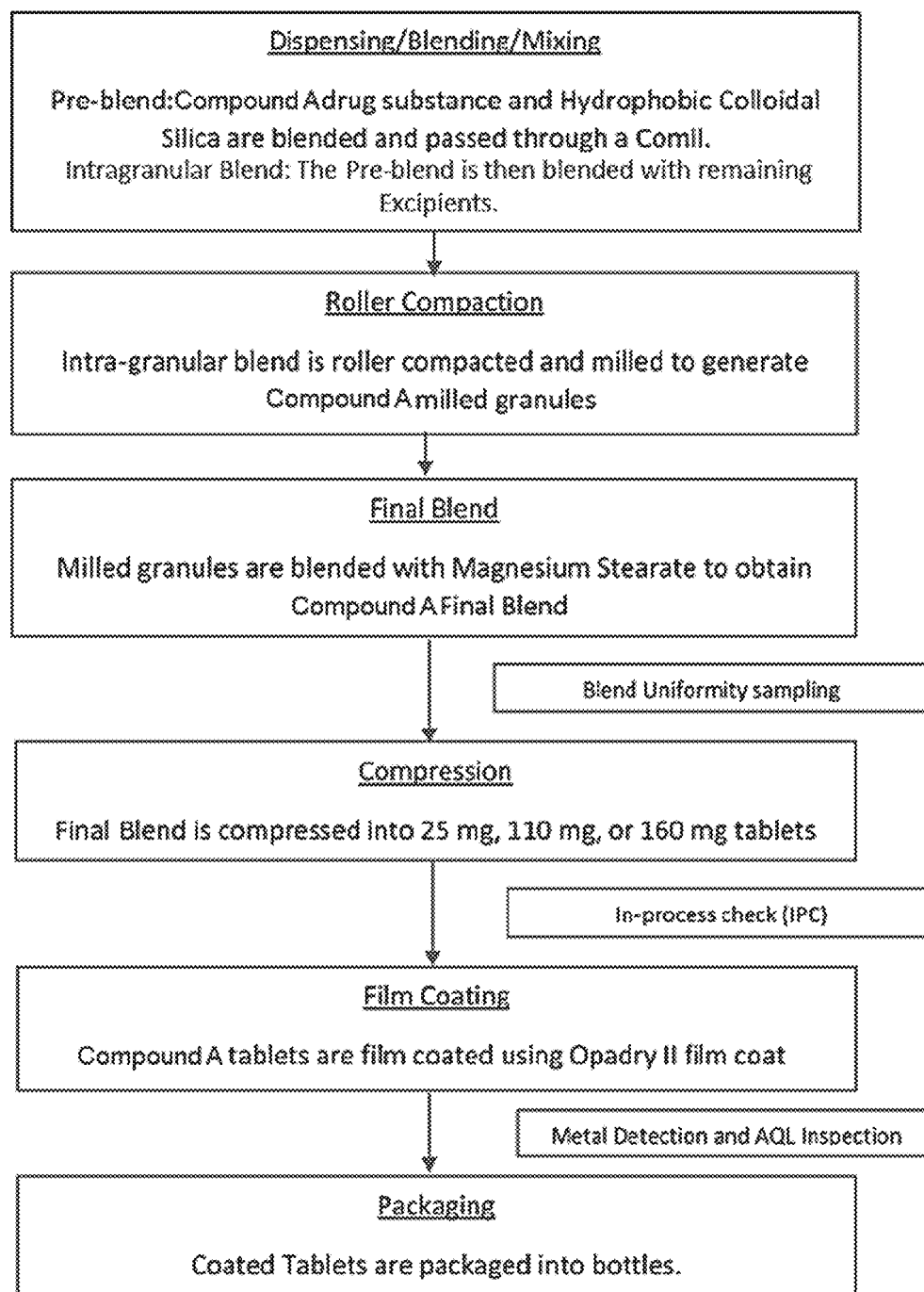


FIG. 30

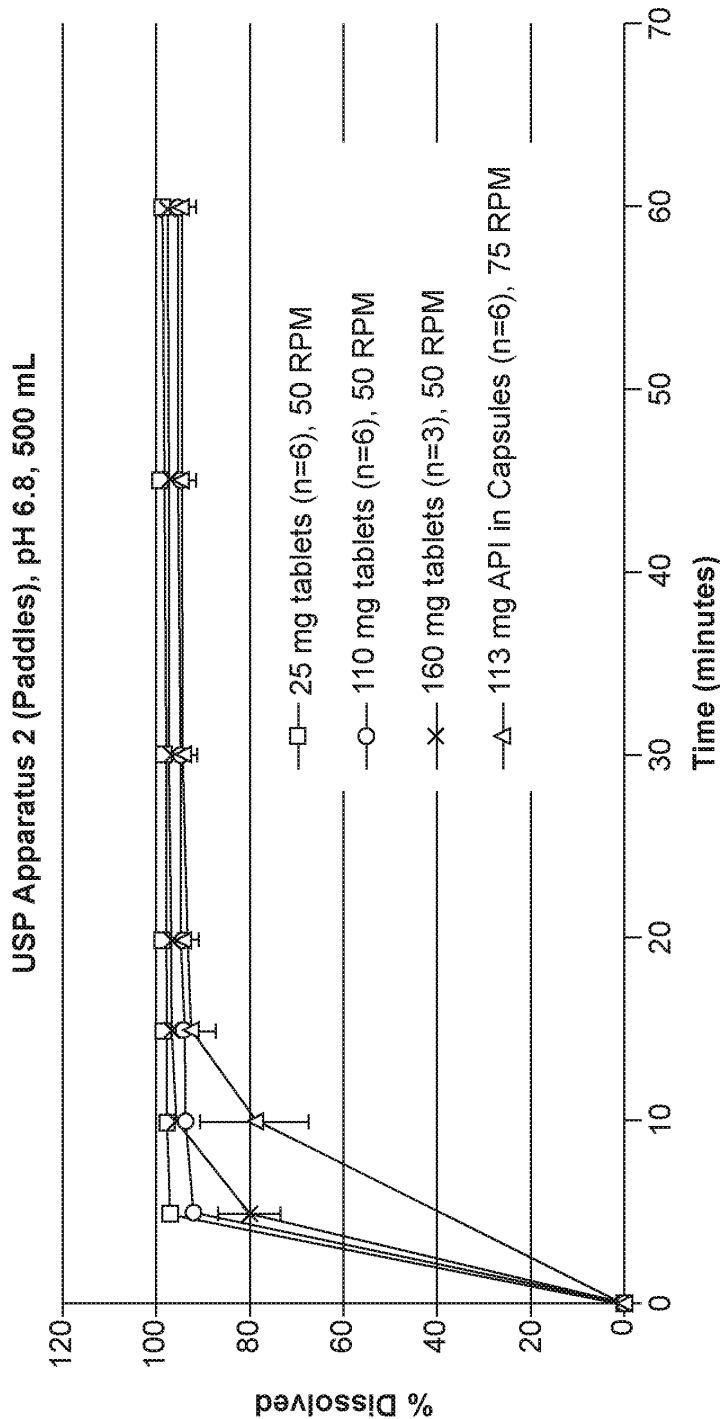


FIG. 31

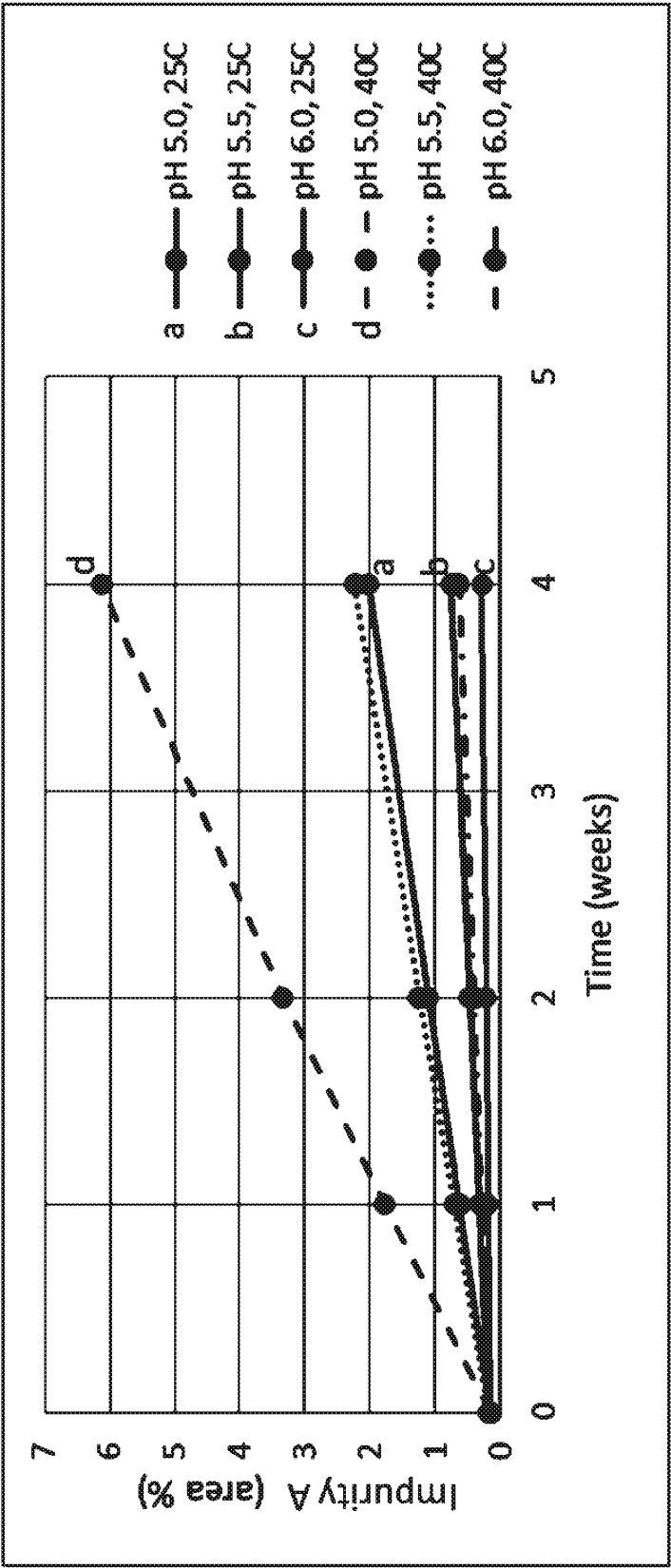


FIG. 32

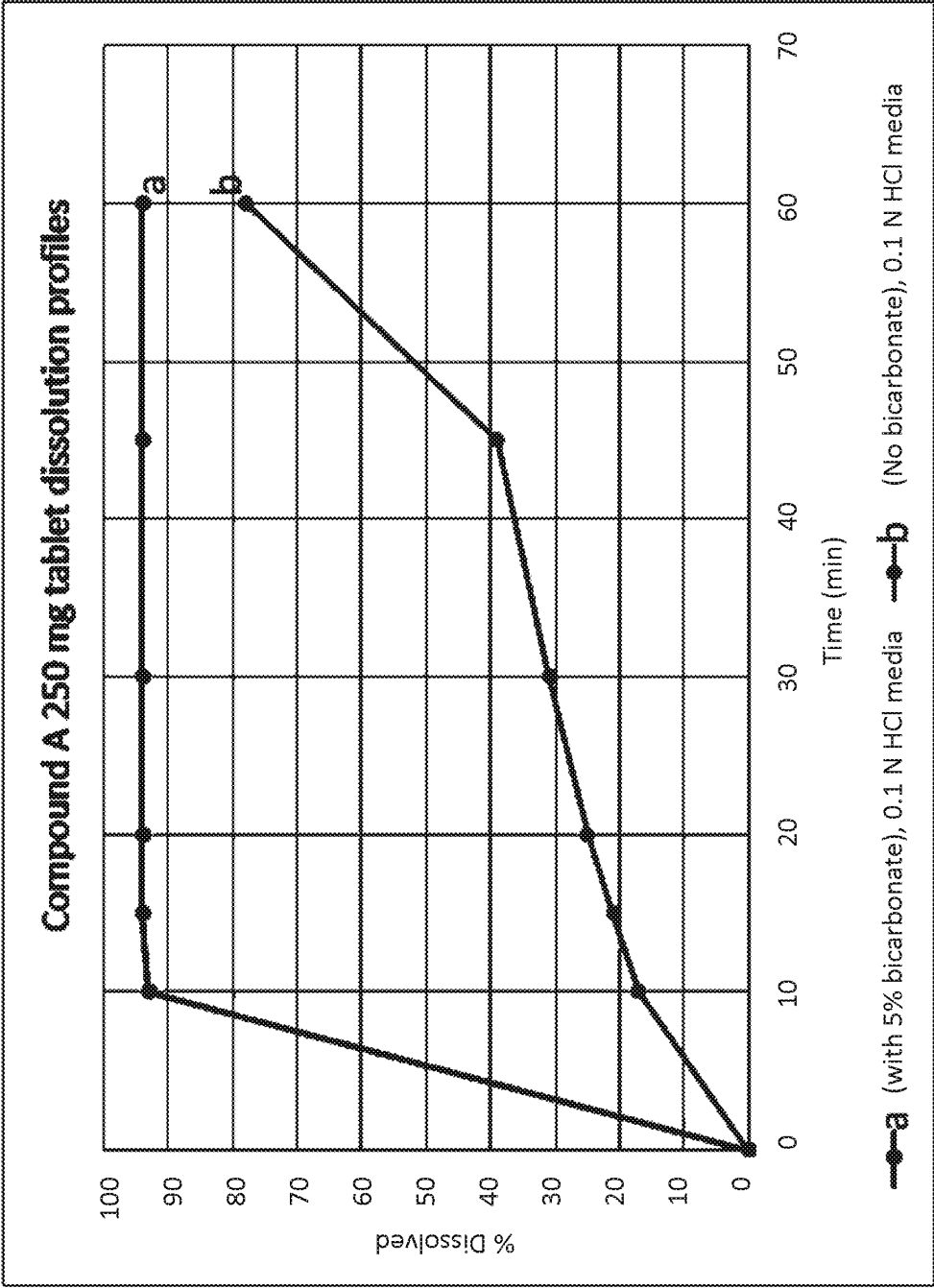


FIG. 33



Path #	Experimental conditions	Crystalline Form
1	Slurry in EtOH or MeOH at RT	Form B (wet-cake); monomethanolate or monoethanolate
2	Drying under ambient condition	Form A (dry solids); monohydrate
3	Slurry in MeCN in presence of Form C seeds at RT	Form C (wet-cake); most likely metastable MeCN solvate which converts to monohydrate
4	MeCN/water system (aw= 0.0-0.6) in presence of Form C seeds at RT	Form C (wet-cake); most likely metastable MeCN solvate which converts to monohydrate
5	Water at RT	Form A (dry solids); monohydrate
6	(95/5v/v) EtOH/water at RT	Form A (dry solids); monohydrate

FIG. 34